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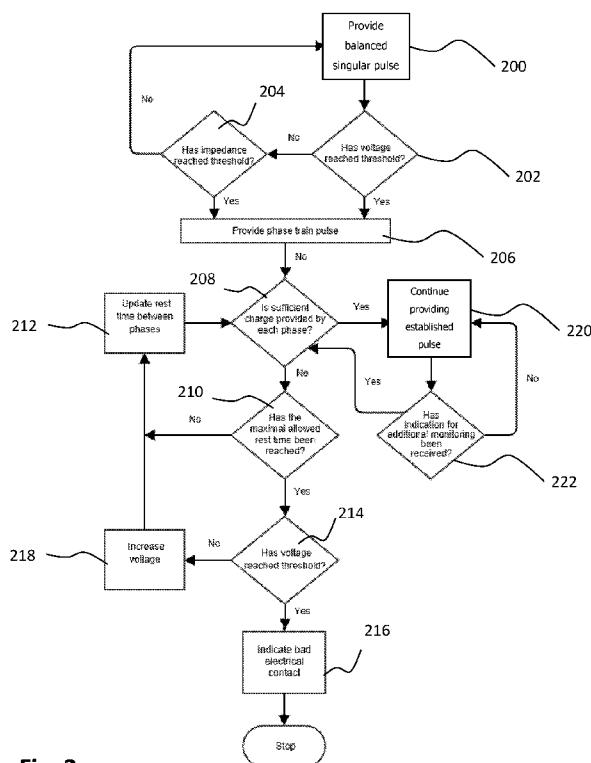
(54) Title: METHOD AND DEVICE FOR TRANSDERMALLY APPLYING ELECTRICAL STIMULATION TO A REGION OF
THE HEAD HAVING HIGH IMPEDANCE(57) Abstract: A method and apparatus for transdermally provid-
ing electrical current to a region of a user's head at high imped-
ance conditions, while maintaining low voltage levels.

Fig. 2



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Method and Device for Transdermally Applying Electrical Stimulation to a Region of the Head Having High Impedance

FIELD OF THE INVENTION

The present invention relates to apparatus and methods for applying electrical stimulation to the head region, and particularly to areas having high impedance, such as hair covered head regions.

BACKGROUND OF THE INVENTION

The present invention relates to apparatus and methods for applying electrical stimulation to the head region. The disclosed apparatus may be used for stimulation of peripheral and cranial nerves, for transcranial stimulation of brain regions, and for sensing various body parameters.

Peripheral and cranial nerves in the head region may be stimulated to treat various conditions such as chronic pain, migraine, tension headaches, cluster headaches, fibromyalgia, depression, post-traumatic stress disorder (PTSD), anxiety, stress, bipolar disorder, schizophrenia, obsessive compulsive disorder (OCD), insomnia, epilepsy, attention deficit disorder (ADD), attention deficit hyperactivity disorder (ADHD), Parkinson's disease, Alzheimer's disease, obesity, multiple sclerosis, stroke and traumatic brain injury (TBI). The anatomy of peripheral and cranial nerves in the head region, such as that of the occipital and trigeminal nerves, and their projections to brainstem regions such as the locus coeruleus and nucleus raphe magnus, as well as to higher brain regions such as the thalamus and anterior cingulate cortex, may be advantageous when stimulating these nerves for treatment of such conditions.

Neurostimulation of superficial nerves in the head region, such as the occipital, supraorbital, supratrochlear, zygomaticotemporal, and auriculotemporal nerve branches, can be applied either invasively or non-invasively. Due to the challenge of transferring current through the hair, stimulation of cephalic nerves which lie under hair covered regions such as the occipital nerve (greater, lesser and third occipital branches), is typically carried out using implanted or percutaneous nerve stimulators. Such devices include electrodes that are inserted under the scalp and thus bypass the high impedance barrier formed by the hair and scalp. However, implanted nerve stimulation remains an invasive and costly procedure with a high rate of complications including infection, bleeding or

fluid collection under the skin, as well as hardware-related malfunctions such as migration and breakage of the implanted leads and pulse generator failure. Transdermal stimulation of cephalic nerves such as the occipital nerve branches using non-invasive techniques is likely to achieve similar clinical benefits to those of implanted stimulators without the risks and cost associated with an invasive procedure.

Non-invasive application of electrical current to the head, and specifically to regions that are covered by hair, poses numerous challenges. The hair and scalp create a high impedance barrier which makes it difficult to transfer electrical current to underlying nerves. High sensory sensitivity of the scalp and of the periosteum of the skull bone, as well as dermal vulnerability of the scalp tissue to electrical current, are additional considerations while attempting to non-invasively stimulate cephalic nerves.

The relationship between the current provided to a tissue, the impedance in the tissue, and the voltage required to provide the current, is characterized by Ohm's Law: $V=I \cdot Z$, where V (voltage) is the potential difference between two electrodes placed over the head, Z is the impedance of the hair and scalp tissue, and I is the current flowing through the impedance. Thus, the voltage increases substantially proportionally to the impedance or resistance.

Non-invasive stimulation of nerves, such as the greater occipital, requires substantial current amplitude (3-15mA), and high voltage levels (up to 150V) may be needed to transfer the current through the hair and scalp due to the high impedance associated therewith. Such high voltage levels are disadvantageous as they may injure the scalp tissue, be uncomfortable for the user, and/or may be wasteful in consumption of energy so that a large battery may be required in order to enable sufficient treatment time.

The impedance level varies significantly between people and tends to change with time. Several factors were identified as affecting the impedance level:

Non-dynamic factors, or factors related to differences between people, include:

- Capacitive/resistive characteristics of the scalp, for example, the resistive component may be $5K\Omega$ in some people and may reach $20K\Omega$ in others.
- Type of hair, for example, oily hair tends to absorb less water than dry hair and thereby have higher impedance than dry hair.
- Amount and density of hair, for example, denser hair creates higher impedance barrier between the stimulating electrode and the scalp.

Dynamic factors, which may vary between treatments and/or during a specific treatment for the same person, include:

- Proximity and quality of contact between the stimulating electrode and the scalp, which may be affected by the skill of the user when attaching the electrodes, or by changes in the user's position. For example, when the user is supine and the weight of his head presses the occipital electrodes against the surface, the stimulating electrode will be closer to the scalp, so that the impedance will be lower.
- Absorption of conductive medium of the electrodes by the hair. For example, conductive media such as water, saline or conductive gel applied to the electrodes to enhance the flow of current therethrough may gradually be absorbed by the user's hair, thus reducing the resistance of the hair to the flow of current and thereby increasing the conductivity between the electrodes and the scalp.
- Dehydration of the conductive medium, which may be affected by the duration of treatment, environmental conditions, and the like.
- Pressure applied on the electrodes pushing them toward the scalp, for example by adjustment of the headset, by the position of the user, and the like.

Variations to the impedance, and specifically dynamic variations of the impedance in the electrode-scalp interface, may disadvantageously affect the ability to achieve effective and homogeneous stimulation of the target nerves or brain regions and may require constant attention and high skillfulness of the user when operating the device.

There is therefore a recognized need for, and it would be highly advantageous to have, a system and method for effective non-invasive neurostimulation of the head region, specifically at areas that are covered by hair, which system and method monitor the tissue and adapt the output signal to the user's characteristics and to changes over time. It would be of particular advantage for such a system and method to avoid damage to scalp tissue as well as discomfort to the user, and to operate in a safe and robust fashion.

SUMMARY OF THE INVENTION

According to some teachings of the present invention there is provided a method for transdermally applying electrical stimulation to a region of the head of a user, the method including:

- (a) engaging at least two electrodes with a surface of the scalp of the user, the electrodes being functionally associated with an electronic circuit having a compliance voltage;
- (b) delivering via the engaged electrodes a balanced pulse including a positive phase train including a streak of constant current positive phases separated by rest times, the

positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of the positive phases and the negative phases is intended to provide a predetermined amount of charge to the head of the user, wherein:

each of a first time ratio, between a cumulative duration of the rest times between the positive phases in the positive phase train and a cumulative duration of the positive phases, and a second time ratio, between a cumulative duration of the rest times between the negative phases in the negative phase train and a cumulative duration of the negative phases is smaller than a predetermined threshold ratio;

the positive phases and the negative phases have a common phase width w_T ;

and

the rest times between immediate successor phases in the positive phase train and in the negative phase train having a common rest-time value rt^I ;

(c) monitoring an amount of charge delivered by the positive phases and the negative phases, to identify a reduction of charge delivered by one or more of the positive and the negative phases;

(d) upon identification of a reduction, adapting the common rest time value rt^I ; and

(e) repeating steps (b)-(d) until:

the monitoring shows that the predetermined amount of charge has been provided by each of the positive and the negative phases; or

at least one of the first time ratio and the second time ratio reaches the predetermined threshold ratio and a voltage of the balanced pulse reaches a predetermined voltage threshold.

In some embodiments, when each of the first and the second time ratios is less than the predetermined threshold ratio, the adapting includes increasing the common rest-time value, and when each of the first and the second time ratios is equal to or greater than the predetermined threshold ratio, the adapting includes increasing a voltage provided by the electrodes and decreasing the common rest time value to a predetermined minimum rest-time value.

In some embodiments, the adapting further includes adapting the common phase width.

According to some teachings of the present invention there is provided a method for transdermally applying electrical stimulation to a region of the head of a user, the method including:

- (a) engaging at least two electrodes with a surface of the scalp of the user, the electrodes being functionally associated with an electronic circuit having a compliance voltage;
- (b) delivering via the engaged electrodes a balanced pulse including a positive phase train including a streak of constant current positive phases separated by rest times, the positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of the positive phases and the negative phases intended to provide a predetermined amount of charge to the head of the user, wherein each of a first time ratio, between a cumulative duration of the rest times between the positive phases in the positive phase train and a cumulative duration of the positive phases, and a second time ratio, between a cumulative duration of the rest times between the negative phases in the negative phase train and a cumulative duration of the negative phases is smaller than a predetermined threshold ratio;
- (c) monitoring an amount of charge delivered by the positive phases and the negative phases, to identify a reduction of charge delivered by one or more of the positive and the negative phases;
- (d) upon identification of a reduction, adapting at least one the rest time in at least one of the positive phase train and the negative phase train; and
- (e) repeating steps (b)-(d) until:

the monitoring shows that the predetermined amount of charge has been provided by each of the positive and the negative phases; or

at least one of the first time ratio and the second time ratio reaches the predetermined threshold ratio and a voltage of the balanced pulse reaches a predetermined voltage threshold.

In some embodiments, the positive phases in the positive phase train have a common phase width w_p . In some embodiments, the negative phases in the negative phase train have a common phase width w_n . In some embodiments, the positive phases in the positive phase train and the negative phases in the negative phase train have a common phase width w_l .

In some embodiments, rest times between immediate successor phases in the positive phase train have a common rest-time value r^p . In some embodiments, the rest times between immediate successor phases in the negative phase train have a common rest-time value r^n . In some embodiments, the rest times between immediate successor phases

in the positive phase train and in the negative phase train have a common rest-time value rt^1 .

In some embodiments, when each of the first and the second time ratio is less than the predetermined threshold ratio, the adapting includes increasing a duration of the at least one the rest-time, and when each of the first and the second time ratio is equal to or greater than the predetermined threshold ratio, the adapting includes increasing a voltage provided by the electrodes and decreasing a duration of the at least one the rest time to a predetermined minimum rest-time value.

In some embodiments, when each of the first and the second time ratio is less than the predetermined threshold ratio, the adapting includes increasing a duration of each rest-time, and when each of the first and the second time ratio is equal to or greater than the predetermined threshold ratio, the adapting includes increasing a voltage provided by the electrodes and decreasing a duration of each rest time to a predetermined minimum rest-time value.

In some embodiments, the adapting further includes adapting a phase width of at least one the positive phase or at least one the negative phase. In some embodiments, the adapting a phase width includes adapting a phase width of each positive phase and each negative phase.

In some embodiments, a duration of the positive phase train is different from a duration of the negative phase train. In some embodiments, the cumulative duration of the positive phases is different from the cumulative duration of the negative phases. In some embodiments, the cumulative duration of the rest times between the positive phases in the positive phase train is different from the cumulative duration of the rest times between the negative phases in the negative phase train.

In some embodiments, a number of the positive phases in the positive phase train is different from a number of the negative phases in the negative phase train. In some embodiments, a duration of the positive phase train is equal to a duration of the negative phase train. In some embodiments, the cumulative duration of the positive phases is equal to the cumulative duration of the negative phases.

In some embodiments, the cumulative duration of the rest times between the positive phases in the positive phase train is equal to the cumulative duration of the rest times between the negative phases in the negative phase train.

In some embodiments, a number of the positive phases in the positive phase train is equal to a number of the negative phases in the negative phase train.

In some embodiments, the region of the head is a hair covered region of the head. In some embodiments, the engaging includes engaging the electrodes at the hair covered region of the head. In some embodiments, the region of the head includes a cephalic nerve, such that the electrical stimulation is delivered to the cephalic nerve in the region of the head.

In some embodiments, the engaging includes mounting a headset, including the at least two electrodes and the electronic circuit, on the head of the user such that the at least two electrodes engage the surface of the scalp.

In some embodiments, the predetermined threshold ratio is in the range of 0.4-1.2, 0.5-1, or 0.55-0.75. In some embodiments, the predetermined threshold ratio is 0.6.

In some embodiments, a duration of each rest time in the positive phase train and in the negative phase train at least equals a minimum rest time duration. In some embodiments, the minimum rest time duration is 5 μ sec.

In some embodiments, a phase width of each of the positive phases and of each of the negative phases is not greater than a maximal phase width. In some embodiments, the maximal phase width is at most 600 μ sec, at most 400 μ sec, at most 200 μ sec, at most 100 μ sec, or at most 50 μ sec.

In some embodiments, the monitoring is carried out by the electrodes.

In some embodiments, the monitoring is carried out by at least one sensor external to the electrodes, the sensor engaging the skin of the scalp of the user and being functionally associated with the electronic circuit.

In some embodiments, the monitoring includes monitoring a provided waveform for each of the positive and the negative phases, to identify, for each positive and the negative phase, whether the provided waveform is identical to an intended waveform, and wherein the reduction of charge is identified if the provided waveform is not identical to the intended waveform.

In some embodiments, the adapting includes adapting at least one of the first time ratio and the second time ratio. In some embodiments, the adapting includes adapting the first time ratio and the second time ratio.

In some embodiments, the adapting further includes changing a number of the positive phases in the positive phase train. In some embodiments, the adapting further includes changing a number of the negative phases in the negative phase train. In some embodiments, the adapting further includes changing an amplitude of at least one of the positive phases and the negative phases.

In some embodiments, the monitoring further includes the electronic circuit measuring impedance in the electrodes, and wherein the adapting takes place upon identification of the impedance exceeding an impedance threshold.

In some embodiments, the monitoring further includes monitoring a voltage delivered by the electrodes, and wherein the adapting takes place upon identification of the voltage reaching an upper voltage threshold. In some embodiments, the upper voltage threshold is the compliance voltage.

In some embodiments, the method further includes, following the monitoring showing that the predetermined amount of charge has been provided by each of the positive and the negative phases and completion of the step (e), additionally monitoring the amount of charge delivered by the positive and the negative phases, to identify a change in the charge delivered by the positive and the negative phases.

In some embodiments, the change is indicative of a change in conditions in which the positive and the negative phases are provided. In some embodiments, the change in the conditions includes a change in impedance measured between the at least two electrodes.

In some embodiments, the additionally monitoring is carried out periodically.

In some embodiments, the additionally monitoring is carried out intermittently.

In some embodiments, the additionally monitoring is carried out in response to receipt of an indication from the user. In some embodiments, the indication includes an indication of discomfort or pain.

In some embodiments, the additionally monitoring is carried out in response to receipt of a signal from a humidity sensor indicating a change in humidity in an area adjacent the electrodes.

In some embodiments, the additionally monitoring is carried out in response to receipt of a signal from a temperature sensor indicating a change in temperature in an area adjacent the electrodes.

In some embodiments, the additionally monitoring is carried out in response to receipt of a signal from an accelerometer indicating a change in at least one of a position of the user, a position of the electrodes, and pressure applied to the electrodes.

In some embodiments, the additionally monitoring is carried out in response to receipt of a signal from a pressure sensor indicating a change in pressure applied to the electrodes.

In some embodiments, the method further includes, following identification of the change in conditions by the additionally monitoring, repeating the steps (d) and (e) of the method.

In some embodiments, the method further includes, following at least one of the first time ratio and the second time ratio reaching the predetermined threshold ratio and the voltage reaching the predetermined voltage threshold, terminating application of the electrical stimulation, and notifying the user that treatment has been terminated.

In some embodiments, the method further includes, following step (a) and prior to step (b):

delivering via the engaged electrodes a balanced singular constant-current pulse including a positive phase immediately followed by a negative phase, the positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

identifying that impedance in the electronic circuit during delivery of the singular pulse has reached a predetermined impedance threshold.

In some embodiments, the method further includes, following step (a) and prior to step (b):

delivering via the engaged electrodes a balanced singular constant-current pulse including a positive phase immediately followed by a negative phase, the positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

identifying that a voltage required to deliver the singular constant current pulse has reached an upper voltage threshold.

In some embodiments, the upper voltage threshold is the compliance voltage of the electronic circuit.

According to some teachings of the present invention there is provided a head mounted device including:

at least a pair of electrodes, configured, when the head mounted device is donned, to engage the scalp of the user and to deliver to the scalp of the user a balanced pulse including a positive phase train including a streak of constant current positive phases separated by rest times, the positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of the positive phases and the negative phases intended to provide a predetermined amount of charge to the head of the user, wherein:

each of a first time ratio, between a cumulative duration of the rest times between the positive phases in the positive phase train and a cumulative duration of the positive phases, and a second time ratio, between a cumulative duration of the rest times between the negative phases in the negative phase train and a cumulative duration of the negative phases is smaller than a predetermined threshold ratio;

the positive phases and the negative phases have a common phase width w ;
and

the rest times between immediate successor phases in the positive phase train and in the negative phase train having a common rest-time value rt' ;

at least one sensor adapted, when the head mounted device is donned by the user and during transmission of the pulse, to engage the skin of the scalp of the user and to monitor an amount of charge delivered by the positive phases and the negative phases;

an electronic circuit, functionally associated with the at least two electrodes and having a compliance voltage; and

a processing unit, functionally associated with the electrodes to provide instructions thereto and with the at least one sensor to receive input therefrom, the processing unit programmed to:

- (a) receive input from the at least one sensor;
- (b) identify in the received input a reduction of charge delivered by one or more of the positive and the negative phases;
- (c) upon identification of a reduction, to provide input to the electrodes causing adaptation of the common rest time value; and
- (d) repeat steps (a)-(c) until:

the predetermined amount of charge has been provided by each of the positive and the negative phases; or

at least one of the first time ratio and the second time ratio reaches the predetermined threshold ratio and a voltage of the balanced pulse reaches a predetermined voltage threshold.

In some embodiments, the processing unit is further programmed:

when each of the first and the second time ratio is less than the predetermined threshold ratio, to provide input to the electrodes causing the common rest-time value to increase; and

when each of the first and the second time ratio is equal to or greater than the predetermined threshold ratio, to provide input to the electrodes causing a voltage provided

by the electrodes to increase and the common rest time value to decrease to a predetermined minimum rest-time value.

In some embodiments, the processing unit is further configured to provide input to the electrodes causing adaptation of the common phase width.

According to some teachings of the present invention there is provided a head mounted device including:

at least a pair of electrodes, configured, when the head mounted device is donned, to engage the scalp of the user and to deliver to the scalp of the user a balanced pulse including a positive phase train including a streak of constant current positive phases separated by rest times, the positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of the positive phases and the negative phases intended to provide a predetermined amount of charge to the head of the user, wherein each of a first time ratio, between a cumulative duration of the rest times between the positive phases in the positive phase train and a cumulative duration of the positive phases, and a second time ratio, between a cumulative duration of the rest times between the negative phases in the negative phase train and a cumulative duration of the negative phases is smaller than a predetermined threshold ratio;

at least one sensor adapted, when the head mounted device is donned by the user and during transmission of the pulse, to engage the skin of the scalp and to monitor an amount of charge delivered by the positive phases and the negative phases;

an electronic circuit, functionally associated with the at least two electrodes and having a compliance voltage; and

a processing unit, functionally associated with the electrodes to provide instructions thereto and with the at least one sensor to receive input therefrom, the processing unit programmed to:

- (a) receive input from the at least one sensor;
- (b) identify in the received input a reduction of charge delivered by one or more of the positive and the negative phases;
- (c) upon identification of a reduction, to provide input to the electrodes causing adaptation of at least one the rest time in at least one of the positive phase train and the negative phase train; and
- (d) repeat steps (a)-(c) until:

the predetermined amount of charge has been provided by each of the positive and the negative phases; or

at least one of the first time ratio and the second time ratio reaches the predetermined threshold ratio and a voltage of the balanced pulse reaches a predetermined voltage threshold.

In some embodiments, the electrodes are configured to deliver a pulse wherein the positive phases in the positive phase train have a common phase width w_p . In some embodiments, the electrodes are configured to deliver a pulse wherein the negative phases in the negative phase train have a common phase width w_n . In some embodiments, the electrodes are configured to deliver a pulse wherein the positive phases in the positive phase train and the negative phases in the negative phase train have a common phase width w_L .

In some embodiments, the electrodes are configured to deliver a pulse wherein the rest times between immediate successor phases in the positive phase train have a common rest-time value rt^p . In some embodiments, the electrodes are configured to deliver a pulse wherein the rest times between immediate successor phases in the negative phase train have a common rest-time value rt^n . In some embodiments, the electrodes are configured to deliver a pulse wherein the rest times between immediate successor phases in the positive phase train and in the negative phase train have a common rest-time value rt^L .

In some embodiments, the processing unit is further programmed:

when each of the first and the second time ratio is less than the predetermined threshold ratio, to provide input to the electrodes causing a duration of the at least one the rest-time to be increased; and

when each of the first and the second time ratio is equal to or greater than the predetermined threshold ratio, to provide input to the electrodes causing a voltage provided by the electrodes to be increased and a duration of the at least one the rest time to be decreased to a predetermined minimum rest-time value.

In some embodiments, the processing unit is further programmed:

when each of the first and the second time ratio is less than the predetermined threshold ratio, to provide input to the electrodes causing a duration of each rest-time to be increased; and

when each of the first and the second time ratio is equal to or greater than the predetermined threshold ratio, to provide input to the electrodes causing a voltage provided by the electrodes to be increased and a duration of each rest time to be decreased to a predetermined minimum rest-time value.

In some embodiments, the processing unit is further programmed to provide input to the electrodes causing adaptation to a phase width of at least one the positive phase or at least one the negative phase. In some embodiments, the processing unit is further programmed to provide input to the electrodes causing adaptation to a phase width of each positive phase and each negative phase.

In some embodiments, the electrodes are configured to deliver a pulse wherein a duration of the positive phase train is different from a duration of the negative phase train. In some embodiments, the electrodes are configured to deliver a pulse wherein the cumulative duration of the positive phases is different from the cumulative duration of the negative phases. In some embodiments, the electrodes are configured to deliver a pulse wherein the cumulative duration of the rest times between the positive phases in the positive phase train is different from the cumulative duration of the rest times between the negative phases in the negative phase train.

In some embodiments, the electrodes are configured to deliver a pulse wherein a number of the positive phases in the positive phase train is different from a number of the negative phases in the negative phase train. In some embodiments, the electrodes are configured to deliver a pulse wherein a duration of the positive phase train is equal to a duration of the negative phase train. In some embodiments, the electrodes are configured to deliver a pulse wherein the cumulative duration of the positive phases is equal to the cumulative duration of the negative phases.

In some embodiments, the electrodes are configured to deliver a pulse wherein the cumulative duration of the rest times between the positive phases in the positive phase train is equal to the cumulative duration of the rest times between the negative phases in the negative phase train. In some embodiments, the electrodes are configured to deliver a pulse wherein a number of the positive phases in the positive phase train is equal to a number of the negative phases in the negative phase train.

In some embodiments, the device further includes a body member adapted to be donned on the head of a user, wherein the electrodes and the sensor are mounted onto an inner surface of the body member.

In some embodiments, the region of the head is a hair covered region of the head. In some embodiments, the electrodes are configured, when the head mounted device is donned, to engage the hair covered region of the head. In some embodiments, the region of the head includes a cephalic nerve, such that the electrodes are configured to deliver the electrical stimulation to the cephalic nerve in the region of the head.

In some embodiments, the predetermined threshold ratio is in the range of 0.4-1.2, 0.5-1, or 0.55-0.75. In some embodiments, the predetermined threshold ratio is 0.6.

In some embodiments, the electrodes are configured to deliver a pulse wherein a duration of each rest time in the positive phase train and in the negative phase train is at least equal to a minimum rest time duration. In some embodiments, the minimum rest time duration is 5µsec.

In some embodiments, the electrodes are configured to deliver a pulse wherein a phase width of each of the positive phases and of each of the negative phases is not greater than a maximal phase width. In some embodiments, the maximal phase width is at most 600 µsec, at most 400 µsec, at most 200 µsec, at most 100 µsec or at most 50 µsec.

In some embodiments, the at least one sensor is at least one of the electrodes.

In some embodiments, the at least one sensor is external to the electrodes and is functionally associated with the electronic circuit.

In some embodiments, the at least one sensor is configured to monitor a provided waveform of each of the positive and the negative phases, and wherein the processing unit is configured to identify, for each positive and the negative phase, whether the provided waveform is identical to an intended waveform, and to identify the reduction of charge if the provided waveform is not identical to the intended waveform.

In some embodiments, the processing unit is configured to provide to the electrodes instruction for adapting at least one of the first time ratio and the second time ratio. In some embodiments, the processing unit is configured to provide to the electrodes instruction for adapting the first time ratio and the second time ratio.

In some embodiments, the processing unit is configured to provide to the electrodes instructions for changing a number of the positive phases in the positive phase train. In some embodiments, the processing unit is configured to provide to the electrodes instructions for changing a number of the negative phases in the negative phase train. In some embodiments, the processing unit is configured to provide to the electrodes instructions for changing an amplitude of at least one of the positive phases and the negative phases.

In some embodiments, the at least one sensor is configured to monitor impedance in the electronic circuit, and the processing unit is configured to identify the impedance exceeding an impedance threshold.

In some embodiments, the at least one sensor is configured to monitor a voltage delivered by the electrodes, and the processing unit is configured to identify the voltage

reaching an upper voltage threshold. In some embodiments, the upper voltage threshold is the compliance voltage.

In some embodiments, following the processing unit identifying that the predetermined amount of charge has been provided by each of the positive and the negative phases and completion of the step (d), the processing unit is configured to receive additional input at least from the at least one sensor and to identify at least one of a change in the charge delivered by the positive and the negative phases and a change in conditions in which the positive and the negative phases are provided.

In some embodiments, the at least one sensor is configured to measure a change in impedance between the at least two electrodes and to provide the measurement to the processing unit as the additional input.

In some embodiments, the device further includes a timer functionally associated with at least one of the processing unit and the at least one sensor, and configured to trigger the at least one sensor to provide the additional input periodically.

In some embodiments, the device further includes a user interface functionally associated with the processing unit, wherein the additional input includes input provided by the user via the user interface. In some embodiments, the additional input includes an indication of discomfort or pain provided by the user.

In some embodiments, the device further includes a humidity sensor functionally associated with the processing unit and configured to sense humidity in an area adjacent to the electrodes, and wherein the additional input includes a signal provided from the humidity sensor to the processing unit, the signal indicating a change in humidity in an area adjacent the electrodes.

In some embodiments, the device further includes a temperature sensor functionally associated with the processing unit and configured to sense a temperature in an area adjacent to the electrodes, and wherein the additional input includes a signal provided from the temperature sensor to the processing unit, the signal indicating a change in temperature in an area adjacent the electrodes.

In some embodiments, the device further includes an accelerometer functionally associated with the processing unit and configured to sense at least one of a position of the user and a position of the electrodes, and wherein the additional input includes a signal provided from the accelerometer to the processing unit, the signal indicating a change in at least one of a position of the user, a position of the electrodes, and pressure applied to the electrodes.

In some embodiments, the device further includes a pressure sensor functionally associated with the processing unit and configured to sense pressure applied to the electrodes, and wherein the additional input includes a signal provided from the pressure sensor to the processing unit, the signal indicating a change in pressure applied to the electrodes.

In some embodiments, the processing unit is further configured, following identification of the change in conditions, to repeat the steps (c) and (d).

In some embodiments, the device further includes a user notification module functionally associated with the processing unit and wherein, following at least one of the first time ratio and the second time ratio reaching the predetermined threshold ratio and the voltage reaching the predetermined voltage threshold, the processing unit terminates application of the electrical stimulation, and the user notification module notifies the user that treatment has been terminated.

In some embodiments, the electrodes are configured to deliver, prior to delivery of the positive phase train and the negative phase train a balanced singular constant-current pulse including a positive phase immediately followed by a negative phase, the positive and negative phases intended to provide a predetermined amount of charge to the head of the user, and the processing unit is configured, prior to delivery of the positive phase train and the negative phase train, to identify that impedance in the electronic circuit during delivery of the singular pulse has reached a predetermined impedance threshold.

In some embodiments, the electrodes are configured to deliver, prior to delivery of the positive phase train and the negative phase train, a balanced singular constant-current pulse including a positive phase immediately followed by a negative phase, the positive and negative phases intended to provide a predetermined amount of charge to the head of the user, and the processing unit is configured to identify, prior to delivery of the positive phase train and the negative phase train that a voltage required to deliver the singular constant current pulse has reached the upper voltage threshold, which, in some embodiments, is the compliance voltage of the electronic circuit.

BRIEF DESCRIPTION OF THE FIGURES

The invention is herein described, by way of example only, with reference to the accompanying drawings. With specific reference now to the drawings in detail, it is stressed that the particulars shown are by way of example and for purposes of illustrative discussion of the preferred embodiments of the present invention only, and are presented in

the cause of providing what is believed to be the most useful and readily understood description of the principles and conceptual aspects of the invention. In this regard, no attempt is made to show structural details of the invention in more detail than is necessary for a fundamental understanding of the invention, the description taken with the drawings making apparent to those skilled in the art how the several forms of the invention may be embodied in practice. Throughout the drawings, like-referenced characters are used to designate like functionalities, but not necessarily identical elements.

In the drawings:

Figure 1A is a schematic block diagram of an embodiment of an inventive system for neurostimulation according to an embodiment of the teachings herein;

Figure 1B is a perspective view schematic illustration of an embodiment of the inventive system of Figure 1A in the form of a headset communicating with external data sources according to the teachings herein;

Figure 2 is a flow chart of an embodiment of a method for neurostimulation of a head region having high impedance according to the teachings herein, using the system of Figure 1A;

Figure 3 is a flow chart of an embodiment of a method for personalization of the method of Figure 2 according to the teachings herein;

Figures 4A, 4B, and 4C are schematic illustrations of a pulse transmitted in accordance with an embodiment of the teachings herein when experiencing different impedances, wherein Figure 4A illustrates the current provided by the pulse under standard impedance conditions, Figure 4B illustrates the current provided by the pulse under high impedance conditions, and Figure 4C illustrates the voltage on the electrodes providing the pulse under high impedance conditions;

Figures 5A, 5B, and 5C are schematic illustrations of a pulse including a phase train of positive phases and a phase train of negative phases in accordance an embodiment of the teachings herein, each of the Figures corresponding to a different stage of the method of claim 2, wherein Figure 5A illustrates a phase train pulse which provides sufficient charge, Figure 5B illustrates the phase train pulse similar to that of Figure 5A but not providing sufficient charge, and Figure 5C illustrates a second phase train pulse providing sufficient charge and having longer rest times between phases;

Figure 6A illustrates a table including experimental results showing the change in voltage and in paresthesia following changes to the provided pulse, the experimental results obtained using the system of Figure 1A and the method of Figure 2; and

Figures 6B and 6C provide schematic graphic representations of the change in voltage as a result of the change in the pulse and of a change in paresthesia as a result of a change in the pulse, the data for Figures 6B and 6C derived from the table of Figure 6A.

DETAILED DESCRIPTION

Systems and methods are described herein that apply electrical stimulation to the head region, for stimulation of peripheral and/or cranial nerves, transcranial stimulation of brain regions, and sensing of body parameters, while monitoring the tissue and adapting the electrical stimulation signal to the user's characteristics and to changes over time. The systems and methods ensure effective electrical stimulation while avoiding damage to scalp tissue as well as discomfort to the user, and operate in a safe and robust fashion.

The inventive methods may be applied using a head mounted construction serving as a platform for applying electrical stimulation in accordance with the inventive methods to treat various conditions such as migraine and tension headaches, cluster headaches, fibromyalgia, depression, post-traumatic stress disorder (PTSD), anxiety, obsessive compulsive disorder (OCD), insomnia, epilepsy, attention deficit hyperactivity disorder (ADHD), Parkinson's disease, Alzheimer's disease, obesity, multiple sclerosis, traumatic brain injury (TBI) and stroke.

The quality of contact between the stimulation electrodes and the scalp is a fundamental aspect in the provision of neurostimulation. Given the fact that such contact, and the resulting conductivity are not always optimal, the inventors have developed a method for compensating for reduced conductivity or increased impedance, for example due to presence of hair, lack of humidity, and the like, while maintaining the user's skin integrity, comfort, and ensuring proper neurostimulation.

Electrical stimulation of a pure sensory nerve elicits radiation of a paresthesia sensation along the distribution of the nerve. The existence of paresthesia at the relevant anatomical area is an indication that effective nerve excitation is taking place. Conversely, absence of paresthesia along the distribution of the nerve during stimulation may reflect an inability to reach effective nerve excitation due to inappropriate stimulation parameters such as excessively low intensity, insufficient current density or charge, or due to other reasons such as inappropriate electrode location or high impedance.

Eliciting paresthesia is an important factor also in the treatment of pain. According to the "Gate-control theory", activation of large sensory A β nerve fibers, which is indicated by the paresthesia sensation, leads to inhibition of small diameter nociceptive A δ and C

fibers and thereby impedes the sensation of pain. As such, it is desirable to maintain the user's sensation of paresthesia during neurostimulation treatment. Several aspects of the present invention relate to methods and techniques that are aimed at ensuring that the electrical current is properly and effectively delivered from the electrodes to the target tissues while keeping the voltage applied to the tissue sufficiently low.

Reference is now made to Figure 1A, which is a schematic block diagram of an embodiment of an inventive system for neurostimulation according to an embodiment of the teachings herein.

As seen, a system **100** for neurostimulation may include at least two stimulating electrodes **102**, and in some embodiments may further include at least two sensing electrodes **104**, both the electrodes **102** and **104** functionally associated with an electronic circuit **106**. The stimulating electrodes **102** are adapted to engage the skin of the user's scalp so as to deliver current thereto as described hereinbelow. In some embodiments, one or more of sensing electrodes **104** may be adapted to engage the skin of the user, and may be configured to sense at least one electrical parameter of a body portion of the user, such as, for example, electroencephalogram (EEG), skin conductance response (SCR), impedance plethysmograph (IPG), electromyograph (EMG), and the like.

According to features of the teachings herein, system **100**, and specifically the electronic circuit **106**, may be suited for applying transcranial electrical stimulation using suitable methods such as Transcranial Direct Current Stimulation (tDCS), Transcranial Alternating Current Stimulation (tACS), and Transcranial Random Noise Stimulation (tRNS).

As seen, the electronic circuit **106** may include any one or more of a microcontroller **108**, a high voltage circuit **110**, a stimulation circuit **112**, an internal power supply **114**, a radio-frequency (RF) transceiver **116**, an analog signal processing circuit **118**, a rechargeable battery **120** electrically associated with a charging circuit **122**, a sensor array **124** including one or more of an accelerometer **126**, a temperature sensor **128**, a pressure sensor **130**, and a humidity sensor **132**, and a user interface **134**.

In some embodiments, the electronic circuit **106** may be electrically associated with and powered by rechargeable battery **120** that is electrically connected to internal power supply **114**. In some embodiments, the internal power supply **114** provides power to high voltage circuit **110**, which in turn is electrically connected to stimulation circuit **112**. The charging circuit **122** is electrically associated with rechargeable battery **120**, and may interface with an external power supply, such as a charger **140**. The high voltage circuit

110 provides to stimulation circuit **112** current with voltage in the range of 1 to 150 V.

In some embodiments, the stimulation circuit **112** receives information and/or commands from the microcontroller **108**. The stimulation circuit **112** is configured to provide electrical stimulation pulses to the user's nerve tissues via the stimulation electrodes **102**.

The stimulation circuit **112** may be configured to produce biphasic, charged balanced electrical pulses, mono-phasic electrical pulses, and/or direct current stimulation.

According to still further features of the described preferred embodiments, the stimulation circuit **112** may be configured to produce electrical stimulation within an intensity range of 0-60mA, 0-40mA, 0-20m, or 0-15mA.

According to still further features of the described preferred embodiments, the stimulation circuit **112** may be configured to produce stimulation pulses with a duration of 10-1000µsec, 50-600 µsec, 100-500 µsec.

According to still further features of the described preferred embodiments, the stimulation circuit **112** may be configured to produce stimulation pulses at a frequency of 1-20,000Hz, 1-10,000Hz, 1-500Hz, 10-300Hz, 10-250Hz, 20-180Hz, 30-180Hz or 40-100Hz.

In some embodiments, electronic circuit **106** may include two or more high voltage circuits (not shown) similar to circuit **112**, each high voltage circuit providing current at a voltage of 1-150V, 1-120V, 1-100V, to at least two of stimulation electrodes **102**. In some embodiments, electronic circuit **106** may include at least two isolated output channels (not shown), each output channel providing output to at least two of stimulation electrodes **102**.

In some embodiments, the electronic circuit **106** also includes a feedback & measurements circuit **142**, which collects voltage or current level information from the stimulation electrodes **102**, and provides the collected information to the microcontroller **108**. The microcontroller **108** uses the provided feedback to monitor and control the voltage and current levels in stimulation electrodes **102** via stimulation circuit **112** in accordance with the method disclosed herein with respect to Figures 2 and 3. In some embodiments, the microcontroller **108** may alert the user, for example by providing an audible or tactile indication, or may halt the provision of current for stimulation in the case of an emergency or of incorrect function of the system, as described hereinbelow with reference to Figure 2.

In some embodiments, the microcontroller **108** may instruct the stimulation circuit **112** to output electrical current in various patterns and/or for various periods of time,

and/or may instruct the stimulation circuit **112** with regards to various stimulation parameters, such as the current amplitude, pulse frequency, phase duration, and amplitude of the current output by the stimulation circuit, as described hereinbelow with reference to Figure 2.

In some embodiments, the microcontroller **108** may instruct the stimulation circuit **112** to provide an output signal having a different pattern for each of a plurality of activated pairs of electrodes. For example, the stimulation circuit **112** may stimulate one pair of electrodes at a pulse frequency of 50Hz and a phase duration of 300μsec and another pair of electrodes at a pulse frequency of 100Hz and a phase duration of 200μsec. In some embodiments, at any given time the microcontroller **108** may activate only one pair of electrodes, may activate a combination of electrodes, and/or may activate several electrodes simultaneously, sequentially, or alternately.

In some embodiments, some electrodes **102** may provide as output an alternating current signal, whereas other electrodes **102** may provide as output a direct current. In some embodiments, at least two electrodes **102** may alternate the type of current provided as output between alternating current and direct current.

In some embodiments, during direct current stimulation in which excitation of a certain region of the brain is determined based on the polarity of an electrode which is positioned above that region of the brain, at least one electrode **102** may be assigned by the microcontroller **108** to be the anode, or positively charged electrode, and at least one other electrode **102** may be assigned to be the cathode, or negatively charged electrode.

In some embodiments, stimulation patterns determined by or assigned by the microcontroller **108** as described hereinbelow with reference to Figure 2, as well as feedback data received from electrodes **102** and/or from sensing electrodes **104** may be stored in the microcontroller **108** or in a volatile or non-volatile memory (not shown) associated therewith. In some embodiments, the stored stimulation patterns may be used to create a personalized neurostimulation protocol for the user, as described hereinbelow with reference to Figure 3.

In some embodiments, electronic circuit **106** may be configured to receive analog signal input, such as electroencephalogram (EEG) signals, skin conductance response (SCR) signals, impedance plethysmograph (IPG) signals, electromyograph (EMG) signals, or other bio-signals, from one or more sensors, such as sensing electrodes **104**, which bio-signals may be indicative of the impedance of the tissue receiving the neurostimulation signal, the charge provided to the tissue, or the like. The analog signal input received from

sensing electrodes **104** may be processed by analog signal processing circuit **118**, and may be transferred therefrom to microcontroller **108**. In some embodiments, electronic circuit **106** may be configured to receive digital, analog, or other input from additional sensors adapted to sense the vicinity of the user or characteristics thereof. In some embodiments, one or more stimulation parameters may be altered by the microcontroller **108** due to inputs received from one or more of the additional sensors, as described hereinbelow.

In some embodiments, accelerometer **126**, or any other suitable orientation sensor, may be configured to sense the angular position of the user's head or of the system **100** (and particularly portions thereof engaging the user's head), and thereby may enable microcontroller **108** to identify a change in the user's and/or system's conditions and to adjust or adapt the pulse provided by stimulating electrodes **102**. For example, a change in the position of the user may result in a change in the pressure applied to the electrodes, thus changing how close the electrodes are to the user's skin and consequently changing the impedance in the system and requiring adaptation of the pulse applied to the tissue via the electrodes, as described hereinbelow.

In some embodiments, temperature sensor **128** may be configured to sense a temperature in the vicinity of the system **100** or of the stimulating electrodes **102**, and thereby may enable microcontroller **108** to identify a change in the user's and/or system's conditions and to adjust or adapt the pulse provided by stimulating electrodes **102**. For example, an increase in the temperature in the vicinity of the user or of the electrodes **102** may result in more rapid dehydration of the electrodes or of conducting material applied thereto, thus increasing the impedance in the system and requiring adaptation of the pulse applied to the tissue via the electrodes, as described hereinbelow.

In some embodiments, pressure sensor **130** may be configured to sense pressure applied to the user's head in the vicinity of electrodes **102** or pressure applied directly to electrodes **102**, and thereby may enable microcontroller **108** to identify a change in the user's and/or system's conditions and to adjust or adapt the pulse provided by stimulating electrodes **102**. For example, an increase in the amount of pressure applied to electrodes **102** pushing them towards the user's scalp is expected to reduce the distance between the electrodes and the scalp, and in some cases the distance between the electrode and the target nerve, thereby reducing the impedance in the system and requiring, or allowing, adaptation of the pulse applied to the tissue via the electrodes, as described hereinbelow.

In some embodiments, humidity sensor **132** may be configured to sense a humidity or moisture level in the vicinity of the system **100** or of the stimulating electrodes **102**, and

thereby may enable microcontroller **108** to identify a change in the user's and/or system's conditions and to adjust or adapt the pulse provided by stimulating electrodes **102**. For example, a decrease in the sensed humidity in the vicinity of the electrodes **102** may be indicative of dehydration of the electrodes or of conducting material applied thereto, thus increasing the impedance in the system and requiring adaptation of the pulse applied to the tissue via the electrodes, as described hereinbelow.

In some embodiments, user interface **134** may be configured to receive from the user an indication of the sensation the user is feeling, such as an indication of pain, an indication of discomfort, or an indication of decreased, or no, paresthesia. Such an indication from the user of a change in the sensation the user feels may enable microcontroller **108** to adjust or adapt the pulse provided by stimulating electrodes **102**.

In some embodiments, RF transceiver **116** may enable the microcontroller **108** to communicate with an interface of an external device **150**, such as a mobile phone, a tablet, a computer, or a cloud based database, by way of radio frequency. The RF transceiver **116** may transmit digital information to and may receive digital information from the microcontroller **108**, for example for personalization of the neurostimulation provided by system **100**, as described hereinbelow with reference to Figure 3.

The interface of device **150** may comprise a software application that may be downloadable from a readily accessible resource, such as from the Internet. The interface may provide to a user thereof an indication, for example by way of a display, of the status of the system **100**, including, for example, information relating to active stimulation channels, stimulation intensity, active program, treatment time, battery status, and RF communication status, as well as various alerts such as alerts relating to electrode contact quality and to proper or improper system alignment on the head. Additionally, the interface may provide to the user, for example by way of a display, usage logs and/or reports, such as information relating to daily stimulation time, stimulation parameters which were used during stimulation, and treatment programs which were used. The interface may also display, or otherwise provide, to the user raw or processed information received from sensors included in or associated with the headset.

In some embodiments, the system may be controlled remotely via the interface of external device **150**. For example, the external interface may enable a user thereof to activate or turn off the system, start or pause stimulation, adjust the stimulation intensity for one or more channels, and select a treatment program. In some embodiments, information collected by the microprocessor **108** may be transmitted, via the external

interface, to a remote location, such as a cloud based portal, where the information may be stored or may be analyzed and/or monitored, for example as described hereinbelow with reference to Figure 3.

Reference is now made to Figure 1B, which is a perspective view schematic illustration of an embodiment of the inventive system **100** of Figure 1A in the form of a headset communicating with external data sources according to the teachings herein.

As seen, a headset **160** may implement the system **100** of Figure 1A, and may be configured to include an anterior member **162** connected to a pair of flexible arm members **164**, which may also be called interim members, each terminating in a posterior member **166**. Anterior member **162**, flexible arm members **164**, and posterior members **166** together form the headset body.

In some embodiments, each posterior member **166** comprises a terminal portion having a tapered end terminating in a closure mechanism **168**.

Anterior member **162** may be configured to contain, on an interior surface thereof, one or more anterior electrode systems **172**, and each of posterior members **166** may be configured to contain, on an interior surface thereof, one or more posterior electrode systems **174**, electrode systems **172** and **174** implementing or being similar to stimulating electrodes **102** of Figure 1A. Each of electrode systems **172** and **174** may comprise an electrode base and a disposable electrode unit, which may, in some embodiments, be structured and functional as described in patent application publications US2015/0374971, AU2015227382, EP2981326, CN105188835, WO2014/141213 and IL241026, all entitled HEADSET FOR TREATMENT AND ASSESSMENT OF MEDICAL CONDITIONS, and WO2016/042499 entitled HEADSET FOR NEUROSTIMULATION AND SENSING OF BODY PARAMETERS filed by the present inventors, which are incorporated by reference as if fully set forth herein.

In some embodiments, electrode systems **172** may comprise anterior electrodes adapted to be located at the supraorbital region of the head over the trigeminal nerve branches for stimulation thereof, or may be electrodes suitable for transcranial stimulation of the frontal and prefrontal region of the brain.

In some embodiments, electrode systems **174** may comprise posterior electrodes adapted to be located at the occipital region of the head over the occipital nerve branches for stimulation thereof, or may be electrodes suitable for transcranial stimulation of the occipital region of the brain.

In some embodiments, one or more of electrode systems **172** and **174** may

comprise sensing electrodes similar to sensing electrodes **104** of Figure 1A, configured to sense at least one electrical parameter of a body portion of said user, such as, for example, electroencephalogram (EEG), skin conductance response (SCR), impedance plethysmograph (IPG), electromyograph (EMG), and the like.

It will be appreciated that headset **160** may include additional electrodes having similar structure and/or functionality to those of electrode systems **172** and **174**. It is further appreciated that electrode systems **172** and/or **174** may be obviated, or moved to other locations on headset **160**, as suitable for stimulating specific nerves or nerve sets, specific brain regions, or for sensing specific parameters. For example, electrode systems **174** may be moved to be along the flexible arm members **164**. As another example, the headset **160** may include only a single pair of electrode systems located on arm members **164**, which electrodes may be configured to be positioned, when the headset is donned, under the hair, while electrode systems **172** and **174** may be obviated.

Anterior member **162** may be configured to contain an electronic circuit **176**, similar to electronic circuit **106** of Figure 1A, which may be configured to be electrically coupled by conductive wires (not shown) to a power source **177**, such as a battery similar to battery **120** of Figure 1A, and to electrodes systems **172** and **174**. In some embodiments, at least a portion of the conductive wires extends to posterior electrode systems **174** via arm members **164**.

In some embodiments, the electronic circuit **176** and/or the battery **177** may be external to headset **160**, and/or may communicate remotely with headset **160**.

As discussed hereinabove with reference to Figure 1A, the electronic circuit **176** may include a stimulation circuit, a microprocessor, a charging circuit and a user interface.

In some embodiments, headset **160** may be configured to connect to an external electronic circuit and/or stimulation circuit, and thereby to transfer electrical current from an external stimulator to the electrode systems **172** and/or **174**. In some embodiments, headset **160** may be configured to connect to at least one external electrode that may be located at various areas of the body. In some embodiments, headset **160** may be configured to connect to an external electronic circuit and processor in order to transfer signals from sensors disposed on the headset **160** to the external processor.

In some embodiments, battery **177** may be disposed within anterior member **162**, and may be recharged by plugging a charger into charging port **178** located, according to certain embodiments, on anterior member **162**.

Anterior member **162** may also be configured to include, on an external surface

thereof, user controls and interface **180**, which may be similar to user interface **134** of Figure 1A. That said, in some embodiments, other portions of headset **160**, such as posterior members **166** or arms **164**, may be configured to include user interface **180**. In some embodiments, user interface **180**, or an additional user interface (not shown) may be external to headset **160** and may communicate with headset **160** remotely, using wired or wireless communication, as explained hereinabove with reference to Figure 1A.

Electronic circuit **176** and user interface **180** may be configured to control and/or activate electrodes included in headset **160**. In some embodiments, user interface **180** is configured to control and/or activate at least two, and in some embodiments more than two, pairs of electrodes. As such, in some embodiments, the stimulation circuit and/or user interface **180** are configured to enable activation of a specific electrode or of a specific pair, or channel, of electrodes, as well as adjustment of the intensity of current supplied by the activated electrodes or of other stimulation parameters of the activated electrodes and provision of user indications such as a user indication of pain, a user indication of discomfort, or a user indication of reduced or increased paresthesia. In some embodiments, any subset of the electrodes may be activated simultaneously, and in some embodiments specific subsets are predefined, for example during manufacture of the electronic circuit **176**. In some such embodiments, user interface **180** enables control not only of a specific electrode or of a specific channel, but also of activated subsets of the electrodes.

In some embodiments, user controls and interface **180** includes a pair of anterior intensity buttons **181a** and **181b** for respectively increasing and decreasing the intensity of stimulation provided by anterior electrode systems **172**, and a pair of posterior intensity buttons **182a** and **182b** for respectively increasing and decreasing the intensity of stimulation provided by posterior electrode systems **174**. It will be appreciated that user control and interface **180** may include similar intensity buttons for each electrode included in the headset **160**.

The user controls and interface **180** may further include a mode changing button **184** for activating and disabling the electronic circuit **176**, as well as for changing between modes of operation of headset **160**. For example, headset **160** may have multiple preset modes of operation, such as a sleep mode, a maintenance mode, and a treatment mode, and repeated operation of button **184** may switch between these modes, in addition to turning the headset on and off.

A user indication button, for example allowing the user to provide a user indication of pain, discomfort, or reduced paresthesia, may form part of user controls and interface

180 and may be disposed on an exterior surface of anterior member **162**.

In some embodiments, the user controls and interface **180** may further include an audio element (not shown), such as a speaker or buzzer, for providing to the user an audible indication of use of the headset **180**, such as an indication of activation of the headset, shutting down of the headset, pressing a button on interface **180**, changing the stimulation mode, and the like.

As explained hereinabove, the electronic circuit and the user interface are configured to control and/or activate electrodes included in headset **160**. In some embodiments, the user interface is configured to control and/or activate at least two, and in some embodiments more than two, pairs of electrodes. As such, in some embodiments, the stimulation circuit and/or the user interface are configured to enable activation of a specific electrode or of a specific pair, or channel, of electrodes, as well as adjustment of the intensity of current supplied by the activated electrodes or of other stimulation parameters of the activated electrodes. In some embodiments, any subset of the electrodes may be activated simultaneously, and in some embodiments specific subsets are predefined, for example during manufacture of the electronic circuit. In some such embodiments, the user interface enables control not only of a specific electrode or of a specific channel, but also of activated subsets of the electrodes.

In some embodiments, electronic circuit **176** includes a transceiver **196**, similar to transceiver **116** of Figure 1A, which transceiver is configured to remotely communicate with a communication device **197** external to headset **160** and similar to external device **150** of Figure 1A, such as a mobile telephone, a tablet computer, and the like. Communication device **197** may further communicate with a remote storage location, such as a cloud based storage location indicated by reference numeral **198**, for storage of data therein or retrieval of data thereof. For example, in some embodiments, data relating to the specific stimulation protocol used for a specific user may be transmitted from transmitter **196** to cloud based storage location **198** for storage therein via communication device **197**, and may be retrieved from the cloud based storage location in the future in order to facilitate personalization of the stimulation protocol for the specific user, substantially as described hereinbelow with reference to Figure 3. As another example, reference data may be transmitted from cloud computing storage location **198** to transceiver **196**, for example via communication device **197**, in order to facilitate personalization of the stimulation protocol as described herein with reference to Figure 3.

Reference is now made to Figure 2, which is a flow chart of an embodiment of a

method for neurostimulation of a head region having high impedance according to the teachings herein, using the system of Figure 1A.

Initially, at step **200**, the microcontroller **108** instructs the stimulation circuit **112** to provide, via the stimulation electrodes **102** that engage the user's scalp surface, one or more electrically balanced singular pulses, each having a single positive phase and a single negative phase. An example of such a pulse, provided under standard impedance conditions, is illustrated in Figure 4A as pulse **400**. In some embodiments, the pulse may have an intensity range of 0-60mA, 0-40mA, 0-20m, or 0-15mA. In some embodiments, the pulse may have a duration of 10-2000µsec, 100-1600 µsec, 200-1400 µsec, or 300-1000 µsec. In some embodiments, the pulse may have a frequency in the range of 1-20,000Hz, 1-10,000Hz, 1-500Hz, 10-300Hz, 10-250Hz, 20-180Hz, 30-180Hz or 40-100Hz.

The microcontroller **108** continuously, periodically or intermittently evaluates whether the voltage required by the electrodes to provide the pulse has reached a predetermined threshold value, or upper voltage threshold, at step **202**. The threshold value may be equal to the compliance voltage of the circuit **106**, or may be a fraction or percentage thereof. In some embodiments, the threshold value is 60%-70% of the compliance voltage.

In some embodiments, following evaluation of the voltage required by the electrodes to provide the pulse, or concurrently therewith, the microcontroller **108** evaluates whether the impedance in the system has reached a predetermined impedance threshold value, at step **204**. This would be suitable when predetermined impedance is reached even if voltage threshold is not reached, for example if the pulse is provided at a relatively low current. In some embodiments, the impedance threshold may be greater than 8KΩ, greater than 10KΩ or greater than 12KΩ.

If the voltage has not reached the voltage threshold, and the impedance has not reached the impedance threshold, the microcontroller **108** instructs the stimulation circuit **112** to continue providing, via the stimulation electrodes **102**, a balanced singular pulses at step **200**.

It will be appreciated that when the voltage in the system is insufficient for providing the pulse, or if the impedance in the system is too high, then according to Ohm's law the current provided by the electrodes will be insufficient to allow for the full charge to be provided to the tissue. Figure 4B illustrates an example of the current provided by

singular pulse **400** under high impedance conditions, and as can be seen, the positive phase of the pulse is cut beginning at a time point indicated by reference numeral **410**, such that the pulse does not provide the charge intended to be provided. Figure 4C illustrates the voltage on the electrodes **102** under high impedance conditions, and as seen the voltage required by the electrodes rises until an upper voltage threshold is reached. In the illustrated embodiment, the upper voltage threshold is the compliance voltage of the system. Comparison of Figures 4B and 4C demonstrates that the time point **410**, where the pulse becomes cut (Figure 4B), corresponds to the time at which the compliance voltage was reached (Figure 4C).

As such, if the evaluation at step **202** determines that the voltage has reached the voltage threshold, and/or if the evaluation at step **204** determines that the impedance has reached the impedance threshold, the pulse provided by the electrodes **102** will be cut. Consequently, at step **206** the microcontroller **108** instructs the stimulation circuit **112** to change the pulse provided via electrodes **102** to be a phase train pulse, similar to the pulse shown in Figure 5A. Referring also to Figure 5A, it is seen that the pulse now provided by the electrodes **102** is a balanced pulse **500** including a positive phase train **502** immediately followed by a negative phase train **508**. The positive phase train **502** includes a streak of constant current positive phases **504** separated by rest times **506**, and the negative phase train **508** includes a streak of constant current negative phases **510** separated by rest times **512**. Each of the positive phases **504** and the negative phases **510** is intended to provide a predetermined amount of charge. It will be appreciated that the term “predetermined amount of charge” relates to an amount of charge equal to the intended amount of charge, as well as to an amount of charge differing from the intended amount of charge by at most 15%, at most 10%, at most 5%, at most 3%, or at most 1%.

The inventors have found that the transition from the singular pulse of Figure 4A to the phase-train pulse of figure 5A results in the reduction of the impedance of the layers underlying the electrodes, such as the hair and tissue layers, and consequently in reduction of the voltage required to provide the required charge. As such, as seen in Figure 5A, in each of the phases **504** and **510** the pulse is complete, and the intended amount of charge, or an amount of charge deviating from the intended amount of charge by at most 15%, at most 10%, at most 5%, at most 3%, or at most 1% is provided to the scalp of the user.

It is a particular feature of the teachings herein that a time ratio tr^p between a cumulative duration d_{r^p} of the rest times **506** between the positive phases **504** and a cumulative duration d_s^p of the positive phases **504** is smaller than a predetermined ratio.

Similarly, a time ratio tr^n between a cumulative duration d_{rt}^n of the rest times **512** between the negative phases **510** and a cumulative duration d_s^n of the negative phases **510** is smaller than a predetermined threshold ratio. In some embodiments, the predetermined threshold ratio is in the range of 0.4-1.2, 0.5-1 or 0.55-0.75. In some embodiments, the predetermined threshold ratio is 0.6, as explained hereinbelow in Example 1.

In some embodiments, such as the embodiment of Figure 5A, the positive phases **504** and the negative phases **510** have a common phase width w_l . However, in other embodiments, the positive phases **504** may have a common phase width w_p , which may be different from a common phase width w_n of the negative phases **510**. In yet further embodiments, the positive phases need not have a common phase width, and the negative phases need not have a common phase width. It will be appreciated that for the purposes of this specification and the claims that follow the term “common phase width” relates to an equal phase width, but also includes phase widths with at most 20%, at most 15%, at most 10%, at most 5%, or at most 1% deviation from one another.

In some embodiments, the rest times **506** between immediate successor positive phases **504** and the rest times **512** between immediate successor negative phases **510** have a common rest-time value rt^l . In other embodiments, the rest times **506** between immediate successor positive phases **504** have a common rest time value rt^p , which may be different from a common rest time value rt^n of the rest times **512** between immediate successor negative phases **510**. In yet further embodiments, the rest times **506** need not have a common rest time value, and the rest times **512** need not have a common rest time value. It will be appreciated that for the purposes of this specification and the claims that follow the term “common rest time value” relates to an equal rest time values, but also includes rest time values with at most 20%, at most 15%, at most 10%, at most 5%, or at most 1% deviation from one another.

In some embodiments, a duration of the positive phase train **500** is equal to a duration of the negative phase train **508**, though it need not necessarily be equal. In some embodiments, the cumulative duration d_s^p of the positive phases **504** is equal to the cumulative duration d_s^n of the negative phases **510**, though it need not necessarily be equal. In some embodiments, the cumulative duration d_{rt}^p of the rest times **506** between the positive phases **504** is equal to the cumulative duration d_{rt}^n of the rest times **512** between negative phases **510**, though it need not necessarily be equal.

The number of positive phases **504** in positive phase train **502**, and the number of

negative phases **510** in negative phase train **508**, is in the range of 2-30. In some embodiments, the number of positive phases **504** in positive phase train **502** is equal to the number of negative phases **510** in negative phase train **508**, though it need not necessarily be equal.

In some embodiments, the duration of each rest time **506** or **512** is at least 5 μ sec. In some embodiments, the phase width of each positive phase **504** and of each negative phase **510** is at most 600 μ sec, at most 400 μ sec, at most 300 μ sec, at most 200 μ sec, at most 100 μ sec, or at most 50 μ sec.

Returning to Figure 2, following transition to a phase-train pulse at step **206**, the results of the transition are evaluated in an attempt to reach a pulse which requires the lowest voltage, while providing sufficient charge to the user's scalp. As such, at step **208** the microcontroller **108** evaluates, or monitors, whether sufficient charge is being provided by each of the positive phases **504** and the negative phases **510**. It will be appreciated that the charge is considered sufficient if it is equal to the intended charge, or if it deviates from the intended charge by at most 15%, at most 10%, at most 5%, at most 3%, or at most 1%.

In some embodiments, the charge provided by the phases is monitored by sensing electrodes **104**, which, in some embodiments, may be the same electrodes as stimulating electrodes **102**. In some embodiments, the charge is monitored by an additional sensor, external to the stimulating electrodes **102** and sensing electrodes **104**, which is functionally associated with circuit **106**, such as for example a sensor in sensor array **124**.

In some embodiments, the charge is monitored by monitoring a waveform of each provided phase, to identify whether the provided waveform for the phase is identical to an intended waveform, or deviates from the intended waveform by at most 15%, at most 10%, at most 5%, at most 3%, or at most 1%. In some embodiments, a reduction in the charge provided to the scalp, or insufficient charge, is indicated by the provided waveform differing from the intended waveform more than the permissible deviation, and specifically by the provided waveform dropping, or being "cut", toward the end of a phase. Referring additionally to Figure 5B, which shows the phase train pulse **500** of Figure 5A in a situation where insufficient charge is provided, it is seen that the waveform of positive phase **504a** does not form a right angle at the end, or is incomplete, which is indicative of the charge being provided by the phase **504a** to the scalp being less than the intended charge.

If at step **208** it is determined that insufficient charge is being provided, for example by determining that the waveform of the pulse is similar to that shown in Figure

5B, at step **210** the microcontroller **108** evaluates whether the time ratio tr^p , between the cumulative duration d_{rt}^p of the rest times between the positive phases and the cumulative duration d_s^p of the positive phases, and the time ratio tr^n , between the cumulative duration d_{rt}^n of the rest times between the negative phases and the cumulative duration d_s^n of the negative phases, are smaller than a predetermined threshold ratio. Stated differently, at step **210** the microcontroller **108** evaluates whether the cumulative rest time in the pulse is less than the maximal allowed rest time, or is equal to the maximal allowed rest time.

If at step **210** the microcontroller **108** determines that the maximal allowed rest time has not been reached, at step **212** the microcontroller **108** instructs the stimulation circuit **112** to update at least one rest time in the provided pulse. Due to the fact that the maximal allowed rest time has not been reached, the microcontroller updates the pulse by increasing at least one rest time in the positive phase train and/or in the negative phase train.

In some embodiments, the microcontroller **108** instructs the stimulation circuit **112** to update the pulse by increasing all the rest times in the positive phase train, and/or all the rest times in the negative phase train. In some embodiments, the microcontroller **108** instructs the stimulation circuit **112** to increase the common rest time value rt^p in the positive phase train, the common rest time value rt^n in the negative phase train, or the common rest time value rt^l in the pulse.

Figure 5C illustrates the phase train pulse **500** of Figures 5A and 5B, following an increase in the common rest time between the phases. As seen in Figure 5C, in some cases, following the increase in the rest times, the pulse waveform is once again “complete” and the expected amount of charge is being provided by the pulse to the scalp of the user.

If the maximal allowed rest time has been reached at step **210**, at step **214** the microcontroller **108** evaluates whether the voltage provided by the electrodes has reached a predetermined voltage threshold, such as the compliance voltage of the system or a predetermined fraction or percentage thereof.

If at step **214** the microcontroller **108** determines that the voltage threshold has been reached, that means that the rest times cannot be increased (due to the determination at step **210**), and the voltage cannot be increased (due to the determination at step **214**). As such, it is likely that there is a bad electrical contact between the electrodes **102** and the user’s scalp, or another malfunction in the system, and at step **216** the microcontroller **108** may provide to the user an indication of such a malfunction or bad electrical contact, for

example via user interface 134. Subsequently, treatment is aborted.

Alternately, if at step 214 the microcontroller 108 determines that the voltage threshold has not been reached, at step 218 the microcontroller 108 instructs the stimulation circuit 112 to increase the voltage to be applied by electrodes 102, and subsequently updates at least one rest time in the provided pulse at step 212. In some embodiments, due to the fact that the maximal allowed rest time has been reached, the microcontroller 108 instructs the stimulation circuit 112 to update the pulse by reducing at least one of the rest times in the positive phase train and/or in the negative phase train.

In some embodiments, the microcontroller 108 instructs the stimulation circuit 112 to update the pulse by reducing all the rest times in the positive phase train, and/or all the rest times in the negative phase train. In some embodiments, the microcontroller 108 instructs the stimulation circuit 112 to reduce the common rest time value rt^p in the positive phase train, the common rest time value rt^n in the negative phase train, or the common rest time value rt^l in the pulse.

In some embodiments, following the increase in voltage at step 218, and the reduction in the rest time at step 212, the phase train pulse has the waveform shown in Figure 5A.

In some embodiments, any rest time reduced by the microcontroller 108 or by stimulation circuit 112 is reduced to a minimal rest time, which, in some embodiments, is not less than 5 μ sec.

It will be appreciated that in some embodiments, the change to the rest times is carried out by microcontroller 108 instructing the stimulation circuit 112 to change one or both of the time ratio tr^p , between a cumulative duration d_{rt}^p of the rest times 506 between the positive phases 504 and a cumulative duration d_s^p of the positive phases 504, and the time ratio tr^n , between a cumulative duration d_{rt}^n of the rest times 512 between the negative phases 510 and a cumulative duration d_s^n of the negative phases 510.

In some embodiments, at step 212 the microcontroller 108 may instruct the stimulation circuit 112 to adapt additional characteristics of the pulse. In some embodiments, at step 212 the microcontroller 108 may also instruct the stimulation circuit 112 to adapt the number of positive phases in the positive phase train and/or the number of negative phases in the negative phase train. In some embodiments, at step 212 the microcontroller 108 may also instruct the stimulation circuit 112 to adapt the phase width of one or more of the positive phases, or a common phase width w_p of the positive phases.

In some embodiments, at step **212** the microcontroller **108** may also instruct the stimulation circuit **112** to adapt the phase width of one or more of the negative phases, or a common phase width w_n of the negative phases. In some embodiments, the microcontroller **108** may also instruct the stimulation circuit **112** to adapt the amplitude of one or more of the positive phases and/or of one or more of the negative phases.

Following the change to the rest times applied by the microcontroller **108** at step **212**, the microcontroller **108** continues to evaluate whether or not sufficient charge is provided by each phase of the pulse at step **208**, and additional updates to the rest-time and/or voltage may be applied.

At any occurrence of step **208**, if the microcontroller **108** determines that sufficient charge is being provided by each phase of the pulse to the scalp of the user, at step **220** the microcontroller **108** instructs the stimulation circuit **112** to continue to provide the pulse as established.

The microcontroller **108** then waits for an indication that additional monitoring is required, at step **222**. When such an indication is provided, the microcontroller returns to step **208** and assesses whether the pulse is providing sufficient charge, and flow continues from there as described hereinabove. Otherwise, the microcontroller continues to provide the established pulse.

In some embodiments, the indication is a microcontroller-internal indication, for example a time indication for periodic monitoring, for example provided every 10 minutes, every 5 minutes, or every 3 minutes. In some such embodiments, additional monitoring may be carried out more frequently at the initial part of the treatment, and then carried out less frequently at later stages of the treatment once the system has reached an equilibrium.

In other embodiments, the indication may be received from a component external to the microcontroller. For example, the indication may be an indication of discomfort, pain, or reduced paresthesia, provided by the user, via user interface **134**.

In some embodiments, the indication may be provided by a sensor sensing a change in the system. For example, microcontroller **108** may receive from a humidity sensor forming part of sensor array **124** a signal indicating a change in the humidity in the vicinity of electrodes **102**, which requires additional monitoring. As another example, microcontroller **108** may receive from a temperature sensor forming part of sensor array **124** a signal indicating a change in the temperature in the vicinity of electrodes **102**, which requires additional monitoring. As a further example, microcontroller **108** may receive from a pressure sensor forming part of sensor array **124** a signal indicating a change in the

pressure applied to electrodes **102**, which requires additional monitoring. As yet another example, the microcontroller **108** may receive from an accelerometer forming part of sensor array **124** a signal indicating a change in the position of the user or in the position of the electrodes, which may indicate that additional monitoring is required (for example, if the user was supine and is now standing, less pressure is applied to the electrodes, which may increase the impedance).

It will be appreciated that in order to evaluate the quality of signal transduction in the system (at step **208**), one may replace the evaluation of the charge provided by the phases of the pulse with an evaluation of the impedance in the system, which, due to Ohm's law, is equivalent to the evaluation of the charge. In such embodiments, the rest times in the provided pulse and/or voltage of the provided pulse would be updated if the impedance measured between the electrodes **102** is above a predetermined impedance threshold. In some embodiments, the impedance threshold may be greater than $8K\Omega$, greater than $10K\Omega$ or greater than $12K\Omega$.

Reference is now made to Figure 3, which a flow chart of an embodiment of a method for personalization of the method of Figure 2 according to the teachings herein.

As seen at step **300**, initially, data for generating a treatment model for a specific user is obtained. In some embodiments, the data may be obtained from a remote database, either based in a server or Cloud based. In some embodiments, the data may be based on specific information relating to the user, such as characteristics of the patient such as age, weight, and hair type, and values collected during previous treatments such as stimulation intensity, impedance levels reached, voltage levels reached, changes in voltage/impedance during treatment, and/or treatment duration.

Subsequently, at step **302**, a treatment model is generated based on default values modified in accordance with the obtained data. In some embodiments, the treatment model takes into consideration currently collected treatment data, such as information relating to the current state of the system as identified by sensors in the system (e.g. sensors in sensor array **124**), which information may include humidity information as identified by a humidity sensor, temperature information as identified by a temperature sensor, position information as identified by an accelerometer, and the like. Additionally, the system may allow the user to provide input, for example via user interface **134**, relating to the current state of the system, and to use the input to generate the treatment model. For example, the user may indicate that skin irritation or excess skin erythema occurred, which can be used

to update the treatment model for this specific user.

At step **304**, the microcontroller of the system generates a prediction of the voltage and/or pulse form that will be required in order to provide sufficient charge to the specific user's scalp, while using a reasonable voltage and short rest times between phases. At step **306**, the prediction is used to initiate treatment in accordance with the method of Figure 2, where the predicted voltage is used as the initial voltage in the treatment.

At step **308**, during and/or after treatment, the actual voltage required in order to provide sufficient charge to the user's scalp and/or parameters of the actual waveform used to provide such charge (for example the number of positive and negative phases, the length of each positive and negative phase, the lengths of the rest times between phases, and the like) are recorded by the microcontroller, and stored in a memory associated therewith.

In some embodiments, the recorded data may be transmitted to a remote database, either located at a remote server or Cloud based, as seen at step **310**. The data may be stored in the remote database, in some embodiments associated with at least one identifier of the specific user, such as an identification number or name of the user, or with at least one identifier of the device used by the user, so that it may be readily used in the next treatment session, for example as the data obtained at step **300**.

Reference is now made to the following example, which together with the above description, illustrates the invention in a non-limiting fashion.

EXAMPLE

Ten users were treated using the system of Figure 1B and the method of Figure 2.

The treatment included stimulation of the greater occipital nerve. A headset, similar to that shown in Figure 1B, was placed on each user's head so that the posterior electrodes were placed under the hair over the left and right greater occipital nerve branches at the level of the external occipital protuberance.

Stimulation in the form of electrically balanced pulses was applied at a constant current of 5mA and at a frequency of 80Hz.

In a baseline round, the provided positive and negative phases were singular phases each having a phase duration of 400 μ sec, as described hereinabove with reference to Figure 4A. The voltage level was recorded. The users were asked to note the intensity of paresthesia felt at the nerve distribution region, and this intensity was considered baseline intensity and assigned a score of 10.

In each subsequent round of treatment, the pulse included a positive phase train and

a negative phase train as described hereinabove with reference to Figure 5A. The cumulative duration of the stimulation phases, or the “on-time” in each of the positive and negative phase trains, remained 400 μ sec. In each round, the cumulative rest time in each phase train was increased, and the resulting change in voltage required to provide the pulse was recorded. Additionally, the users were asked to assign a score of 1-10 to the paresthesia felt in the nerve distribution region, where 10 is the baseline paresthesia and 1 is negligible paresthesia.

The results are summarized in Figure 6A, which illustrates a table including the change in voltage and in paresthesia following the change to the cumulative rest time of the provided pulse.

The table **600** includes a title row **602**, a first baseline row **604**, and a plurality of treatment rows **606**, each relating to a single round of treatment. Each of the rows is divided into a plurality of columns **608**, including:

column **608a** showing the cumulative rest time, in μ sec, in each of the positive and negative phase trains in that round of treatment;

column **608b** showing the percentage of the cumulative length of the rest time from the cumulative phase durations, or, stated differently, the percentage of the “off time” from the “on time” for each of the positive and negative phase trains – for example, if the cumulative rest time is 100 μ sec, and as mentioned above the cumulative phase duration in each phase train in all the rounds is 400 μ sec, then the percentage shown in column **608b** would be 25%;

column **608c** showing the average voltage required in order to provide sufficient charge, given the rest time specified in column **608a**;

column **608d** showing the percent of decrease in average voltage, relative to the baseline voltage; and

column **608e** showing the average paresthesia score provided by users for the treatment round.

Figures 6B and 6C provide schematic graphic representations of the results shown in Figure 6A. Specifically, Figure 6B illustrates the change in voltage as a result of the change in the pulse waveform in the different treatment rounds, and Figure 6C illustrates the change in experienced paresthesia as a result of a change in the pulse waveform in each pulse round.

A closer look at table **600** shows that as the cumulative rest time increases, the voltage required in order to provide sufficient charge to the scalp of the user decreases, as

well as the paresthesia experienced by the user. Looking specifically at the lowest row **606h** of the table **600**, it is seen that the voltage required to provide the pulse, when the cumulative rest time is double the length of the cumulative phase duration, has decreased by as much as 67%, and the paresthesia experienced by the user has decreased entirely, to the point that the users only felt negligible paresthesia, if any.

As seen in Figure 6C, the paresthesia experienced by the users (y-axis) is plotted against the percentage of the total rest time from the total phase duration, or stated differently, the percentage of the total “off time” from the total “on time” (x-axis). As seen, the graph initially decreases at section **620a**, then plateaus at section **620b**, and subsequently decreases at section **620c**, substantially linearly, until reaching the score of 1.

As seen, at the point of the plateau having the greatest rest time percentage, indicated in Figure 6C by reference numeral **622a**, the user still experiences significant paresthesia (with an average score of 8). In the present example, this point is at a rest time percentage of 60%, or a ratio of 0.6 between the cumulative rest time and the cumulative phase duration.

Turning to Figure 6B, it is seen that the percentage of decrease of the voltage required to provide sufficient charge from voltage baseline (y-axis) is plotted against the percentage of the total rest time from the total phase duration, or stated differently, the percentage of the total “off time” from the total “on time” (x-axis). At point **622b**, which corresponds in the rest time percentage to point **622a** of Figure 6C, the voltage required to provide sufficient charge to the user’s scalp is approximately 25% lower than the baseline voltage.

It will be appreciated that in accordance with the illustrated results, the identified rest time percentage of 60% is particularly suitable as the rest time threshold as it significantly reduces the voltage required in order to provide sufficient charge to the user’s scalp, while the user continues to feel significant levels of paresthesia in the nerve distribution region, which is desirable.

As used herein in the specification and in the claims section that follows, the term “or” is considered as inclusive, and therefore the phrase “A or B” means any of the groups “A”, “B”, and “A and B”.

As used herein in the specification and in the claims section that follows, the term “pulse” relates to an electrical signal, for example applied via an electrode or sensed by an electrode.

As used herein in the specification and in the claims section that follows, the term

“phase” relates to a pulse or a portion thereof, having current starting from a zero amplitude, changing to a higher amplitude, and returning to zero amplitude.

As used herein in the specification and in the claims section that follows, the term “positive phase” relates to a phase providing current which flows in the positive direction.

As used herein in the specification and in the claims section that follows, the term “negative phase” relates to a phase providing current which flows in the negative direction.

As used herein in the specification and in the claims section that follows, the term “balanced pulse” relates to a pulse including a positive portion including at least one positive phase and a negative portion including at least one negative phase, such that the magnitude, or charge, of the positive and negative portions is equal, or is within 15%, within 10%, within 5%, within 3%, or within 1% of one another.

As used herein, in the specification and in the claims section that follows, the term “phase train” relates to a pulse including two or more consecutive phases of the same type or magnitude, or in the same direction. For example, a positive phase train includes two or more consecutive positive phases and a negative phase train includes two or more consecutive negative phases. Any phases in the opposite direction, having a charge of up to 30% of the charge of the lowest-charge phase in the phase train, are considered as noise and are disregarded when defining a phase train and identifying consecutive phases. For example, a pulse including two positive phases, then a very small short negative phase, and then additional phases, would be considered a positive phase train, because the small short negative phase is disregarded.

As used herein, in the specification and in the claims section that follows, the term “phase train pulse” relates to a pulse including at least one positive phase train and at least one negative phase train.

As used herein, in the specification and in the claims section that follows, the term “balanced phase train pulse” relates to a balanced pulse including at least one positive phase train and at least one negative phase train.

As used herein, in the specification and in the claims section that follows, the term “singular pulse” relates to a pulse including a single positive phase and/or a single negative phase, and not including a phase train.

It will be appreciated that certain features of the invention, which are, for clarity, described in the context of separate embodiments, may also be provided in combination in a single embodiment. Conversely, various features of the invention, which are, for brevity, described in the context of a single embodiment, may also be provided separately or in any

suitable sub-combination. Similarly, the content of a claim depending from one or more particular claims may generally depend from the other, unspecified claims, or be combined with the content thereof, absent any specific, manifest incompatibility therebetween.

Although the invention has been described in conjunction with specific embodiments thereof, it is evident that many alternatives, modifications and variations will be apparent to those skilled in the art. Accordingly, it is intended to embrace all such alternatives, modifications and variations that fall within the spirit and broad scope of the appended claims.

WHAT IS CLAIMED IS:

1. A method for transdermally applying electrical stimulation to a region of the head of a user, the method comprising:

(a) engaging at least two electrodes with a surface of the scalp of the user, said electrodes being functionally associated with an electronic circuit having a compliance voltage;

(b) delivering via the engaged electrodes a balanced pulse comprising a positive phase train including a streak of constant current positive phases separated by rest times, said positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of said positive phases and said negative phases is intended to provide a predetermined amount of charge to the head of the user, wherein:

each of a first time ratio, between a cumulative duration of said rest times between said positive phases in said positive phase train and a cumulative duration of said positive phases, and a second time ratio, between a cumulative duration of said rest times between said negative phases in said negative phase train and a cumulative duration of said negative phases is smaller than a predetermined threshold ratio;

said positive phases and said negative phases have a common phase width w_T ; and

said rest times between immediate successor phases in said positive phase train and in said negative phase train having a common rest-time value rt^I ;

(c) monitoring an amount of charge delivered by said positive phases and said negative phases, to identify a reduction of charge delivered by one or more of said positive and said negative phases;

(d) upon identification of a said reduction, adapting said common rest time value rt^I ; and

(e) repeating steps (b)-(d) until:

said monitoring shows that said predetermined amount of charge has been provided by each of said positive and said negative phases; or

at least one of said first time ratio and said second time ratio reaches said predetermined threshold ratio and a voltage of said balanced pulse reaches a predetermined voltage threshold.

2. The method of claim 1, wherein:

when each of said first and said second time ratios is less than said predetermined threshold ratio, said adapting comprises increasing said common rest-time value; and

when each of said first and said second time ratios is equal to or greater than said predetermined threshold ratio, said adapting comprises increasing a voltage provided by said electrodes and decreasing said common rest time value to a predetermined minimum rest-time value.

3. The method of claim 1 or claim 2, said adapting further comprising adapting said common phase width.

4. A method for transdermally applying electrical stimulation to a region of the head of a user, the method comprising:

(a) engaging at least two electrodes with a surface of the scalp of the user, said electrodes being functionally associated with an electronic circuit having a compliance voltage;

(b) delivering via the engaged electrodes a balanced pulse comprising a positive phase train including a streak of constant current positive phases separated by rest times, said positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of said positive phases and said negative phases intended to provide a predetermined amount of charge to the head of the user, wherein each of a first time ratio, between a cumulative duration of said rest times between said positive phases in said positive phase train and a cumulative duration of said positive phases, and a second time ratio, between a cumulative duration of said rest times between said negative phases in said negative phase train and a cumulative duration of said negative phases is smaller than a predetermined threshold ratio;

(c) monitoring an amount of charge delivered by said positive phases and said negative phases, to identify a reduction of charge delivered by one or more of said positive and said negative phases;

(d) upon identification of a said reduction, adapting at least one said rest time in at least one of said positive phase train and said negative phase train; and

(e) repeating steps (b)-(d) until:

said monitoring shows that said predetermined amount of charge has been provided by each of said positive and said negative phases; or

at least one of said first time ratio and said second time ratio reaches said predetermined threshold ratio and a voltage of said balanced pulse reaches a predetermined voltage threshold.

5. The method of claim 4, wherein said positive phases in said positive phase train have a common phase width w_p .

6. The method of claim 4 or claim 5, wherein said negative phases in said negative phase train have a common phase width w_n .

7. The method of any one of claims 4 to 6, wherein said positive phases in said positive phase train and said negative phases in said negative phase train have a common phase width w_l .

8. The method of any one of claims 4 to 7, wherein said rest times between immediate successor phases in said positive phase train have a common rest-time value rt^p .

9. The method of any one of claims 4 to 8, wherein said rest times between immediate successor phases in said negative phase train have a common rest-time value rt^n .

10. The method of any one of claims 4 to 9, wherein said rest times between immediate successor phases in said positive phase train and in said negative phase train have a common rest-time value rt^l .

11. The method of any one of claims 4 to 10, wherein:

when each of said first and said second time ratio is less than said predetermined threshold ratio, said adapting comprises increasing a duration of said at least one said rest-time; and

when each of said first and said second time ratio is equal to or greater than said predetermined threshold ratio, said adapting comprises increasing a voltage provided by said electrodes and decreasing a duration of said at least one said rest time to a predetermined minimum rest-time value.

12. The method of claim 11, wherein:

when each of said first and said second time ratio is less than said predetermined threshold ratio, said adapting comprises increasing a duration of each said rest-time; and

when each of said first and said second time ratio is equal to or greater than said predetermined threshold ratio, said adapting comprises increasing a voltage provided by said electrodes and decreasing a duration of each said rest time to a predetermined minimum rest-time value.

13. The method of any one of claims 4 to 12, said adapting further comprising adapting a phase width of at least one said positive phase or at least one said negative phase.

14. The method of claim 13, said adapting a phase width comprising adapting a phase width of each said positive phase and each said negative phase.

15. The method of any one of claims 4 to 14, wherein a duration of said positive phase train is different from a duration of said negative phase train.

16. The method of any one of claims 4 to 15, wherein said cumulative duration of said positive phases is different from said cumulative duration of said negative phases.

17. The method of any one of claims 4 to 16, wherein said cumulative duration of said rest times between said positive phases in said positive phase train is different from said cumulative duration of said rest times between said negative phases in said negative phase train.

18. The method of any one of claims 4 to 17, wherein a number of said positive phases in said positive phase train is different from a number of said negative phases in said negative phase train.

19. The method of any one of claims 1 to 14, wherein a duration of said positive phase train is equal to a duration of said negative phase train.
20. The method of any one claims 1 to 14, wherein said cumulative duration of said positive phases is equal to said cumulative duration of said negative phases.
21. The method of any one claims 1 to 14, wherein said cumulative duration of said rest times between said positive phases in said positive phase train is equal to said cumulative duration of said rest times between said negative phases in said negative phase train.
22. The method of any one claims 1 to 14, wherein a number of said positive phases in said positive phase train is equal to a number of said negative phases in said negative phase train.
23. The method of any one of the preceding claims, wherein the region of the head is a hair covered region of the head.
24. The method of claim 23, wherein said engaging comprises engaging said electrodes at said hair covered region of the head.
25. The method of any one of the preceding claims, wherein said region of the head comprises a cephalic nerve, such that said electrical stimulation is delivered to said cephalic nerve in said region of the head.
26. The method of any one of the preceding claims, wherein said engaging comprises mounting a headset, including said at least two electrodes and said electronic circuit, on the head of said user such that said at least two electrodes engage said surface of the scalp.
27. The method of any one of the preceding claims, wherein a duration of each said rest time in said positive phase train and in said negative phase train at least equals a minimum rest time duration.

28. The method of any one of the preceding claims, wherein a phase width of each of said positive phases and of each of said negative phases is not greater than a maximal phase width.
29. The method of any one of the preceding claims, wherein said monitoring is carried out by said electrodes.
30. The method of any one of the preceding claims, wherein said monitoring is carried out by at least one sensor external to said electrodes, said sensor engaging the skin of the scalp of said user and being functionally associated with said electronic circuit.
31. The method of any one of the preceding claims, wherein said monitoring comprises monitoring a provided waveform for each of said positive and said negative phases, to identify, for each said positive and said negative phase, whether the provided waveform is identical to an intended waveform, and wherein said reduction of charge is identified if said provided waveform is not identical to said intended waveform.
32. The method of any one of the preceding claims, wherein said adapting comprises adapting at least one of said first time ratio and said second time ratio.
33. The method of claim 32, wherein said adapting comprises adapting said first time ratio and said second time ratio.
34. The method of any one of the preceding claims, said adapting further comprising changing a number of said positive phases in said positive phase train.
35. The method of any one of the preceding claims, said adapting further comprising changing a number of said negative phases in said negative phase train.
36. The method of any one of the preceding claims, said adapting further comprising changing an amplitude of at least one of said positive phases and said negative phases.
37. The method of any one of the preceding claims, wherein said monitoring further comprises said electronic circuit measuring impedance in said electrodes, and wherein said

adapting takes place upon identification of said impedance exceeding an impedance threshold.

38. The method of any one of the preceding claims, wherein said monitoring further comprises monitoring a voltage delivered by said electrodes, and wherein said adapting takes place upon identification of said voltage reaching an upper voltage threshold.

39. The method of any one of the preceding claims, further comprising, following said monitoring showing that said predetermined amount of charge has been provided by each of said positive and said negative phases and completion of said step (e), additionally monitoring said amount of charge delivered by said positive and said negative phases, to identify a change in the charge delivered by said positive and said negative phases.

40. The method of claim 39, wherein said change is indicative of a change in conditions in which said positive and said negative phases are provided.

41. The method of claim 40, wherein said change in said conditions comprises a change in impedance measured between said at least two electrodes.

42. The method of any one of claims 39 to 41, wherein said additionally monitoring is carried out in response to receipt of an indication from the user.

43. The method of any one of claims 39 to 42, wherein said additionally monitoring is carried out in response to receipt of a signal from a sensor indicating a change in sensed conditions in an area adjacent said electrodes.

44. The method of any one of claims 39 to 43, further comprising, following identification of said change in conditions by said additionally monitoring, repeating said steps (d) and (e) of said method.

45. The method of any one of the preceding claims, further comprising, following at least one of said first time ratio and said second time ratio reaching said predetermined threshold ratio and said voltage reaching said predetermined voltage threshold, terminating

application of said electrical stimulation, and notifying said user that treatment has been terminated.

46. The method of any one of the preceding claims, further comprising, following step (a) and prior to step (b):

delivering via the engaged electrodes a balanced singular constant-current pulse comprising a positive phase immediately followed by a negative phase, said positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

identifying that impedance in said electronic circuit during delivery of said singular pulse has reached a predetermined impedance threshold.

47. The method of any one of the preceding claims, further comprising, following step (a) and prior to step (b):

delivering via the engaged electrodes a balanced singular constant-current pulse comprising a positive phase immediately followed by a negative phase, said positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

identifying that a voltage required to deliver said singular constant current pulse has reached an upper voltage threshold.

48. A head mounted device comprising:

at least a pair of electrodes, configured, when the head mounted device is donned, to engage the scalp of the user and to deliver to the scalp of the user a balanced pulse comprising a positive phase train including a streak of constant current positive phases separated by rest times, said positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of said positive phases and said negative phases intended to provide a predetermined amount of charge to the head of the user, wherein:

each of a first time ratio, between a cumulative duration of said rest times between said positive phases in said positive phase train and a cumulative duration of said positive phases, and a second time ratio, between a cumulative duration of said rest times between said negative phases in said negative phase train and a

cumulative duration of said negative phases is smaller than a predetermined threshold ratio;

said positive phases and said negative phases have a common phase width w_f ; and

said rest times between immediate successor phases in said positive phase train and in said negative phase train having a common rest-time value rt^f ;

at least one sensor adapted, when said head mounted device is donned by said user and during transmission of said pulse, to engage the skin of the scalp of the user and to monitor an amount of charge delivered by said positive phases and said negative phases;

an electronic circuit, functionally associated with said at least two electrodes and having a compliance voltage; and

a processing unit, functionally associated with said electrodes to provide instructions thereto and with said at least one sensor to receive input therefrom, said processing unit programmed to:

- (a) receive input from said at least one sensor;
- (b) identify in said received input a reduction of charge delivered by one or more of said positive and said negative phases;
- (c) upon identification of a said reduction, to provide input to said electrodes causing adaptation of said common rest time value; and
- (d) repeat steps (a)-(c) until:

said predetermined amount of charge has been provided by each of said positive and said negative phases; or

at least one of said first time ratio and said second time ratio reaches said predetermined threshold ratio and a voltage of said balanced pulse reaches a predetermined voltage threshold.

49. The device of claim 48, said processing unit further programmed:

when each of said first and said second time ratio is less than said predetermined threshold ratio, to provide input to said electrodes causing said common rest-time value to increase; and

when each of said first and said second time ratio is equal to or greater than said predetermined threshold ratio, to provide input to said electrodes causing a voltage provided by said electrodes to increase and said common rest time value to decrease to a predetermined minimum rest-time value.

50. The device of claim 48 or claim 49, said processing unit further configured to provide input to said electrodes causing adaptation of said common phase width.

51. A head mounted device comprising:

at least a pair of electrodes, configured, when the head mounted device is donned, to engage the scalp of the user and to deliver to the scalp of the user a balanced pulse comprising a positive phase train including a streak of constant current positive phases separated by rest times, said positive phase train immediately followed by a negative phase train including a streak of constant current negative phases separated by rest times, each of said positive phases and said negative phases intended to provide a predetermined amount of charge to the head of the user, wherein each of a first time ratio, between a cumulative duration of said rest times between said positive phases in said positive phase train and a cumulative duration of said positive phases, and a second time ratio, between a cumulative duration of said rest times between said negative phases in said negative phase train and a cumulative duration of said negative phases is smaller than a predetermined threshold ratio;

at least one sensor adapted, when said head mounted device is donned by said user and during transmission of said pulse, to engage the skin of the scalp and to monitor an amount of charge delivered by said positive phases and said negative phases;

an electronic circuit, functionally associated with said at least two electrodes and having a compliance voltage; and

a processing unit, functionally associated with said electrodes to provide instructions thereto and with said at least one sensor to receive input therefrom, said processing unit programmed to:

- (a) receive input from said at least one sensor;
- (b) identify in said received input a reduction of charge delivered by one or more of said positive and said negative phases;
- (c) upon identification of a said reduction, to provide input to said electrodes causing adaptation of at least one said rest time in at least one of said positive phase train and said negative phase train; and
- (d) repeat steps (a)-(c) until:

said predetermined amount of charge has been provided by each of said positive and said negative phases; or

at least one of said first time ratio and said second time ratio reaches said predetermined threshold ratio and a voltage of said balanced pulse reaches a predetermined voltage threshold.

52. The device of claim 51, said electrodes configured to deliver a said pulse wherein said positive phases in said positive phase train have a common phase width w_p .

53. The device of claim 51 or claim 52, said electrodes configured to deliver a said pulse wherein said negative phases in said negative phase train have a common phase width w_n .

54. The device of any one of claims 51 to 53, said electrodes configured to deliver a said pulse wherein said positive phases in said positive phase train and said negative phases in said negative phase train have a common phase width w_I .

55. The device of any one of claims 51 to 54, said electrodes configured to deliver a said pulse wherein said rest times between immediate successor phases in said positive phase train have a common rest-time value rt^p .

56. The device of any one of claims 51 to 55, said electrodes configured to deliver a said pulse wherein said rest times between immediate successor phases in said negative phase train have a common rest-time value rt^n .

57. The device of any one of claims 51 to 56, said electrodes configured to deliver a said pulse wherein said rest times between immediate successor phases in said positive phase train and in said negative phase train have a common rest-time value rt^I .

58. The device of any one of claims 51 to 57, said processing unit further programmed:
when each of said first and said second time ratio is less than said predetermined threshold ratio, to provide input to said electrodes causing a duration of said at least one said rest-time to be increased; and

when each of said first and said second time ratio is equal to or greater than said predetermined threshold ratio, to provide input to said electrodes causing a voltage

provided by said electrodes to be increased and a duration of said at least one said rest time to be decreased to a predetermined minimum rest-time value.

59. The device of claim 58, said processing unit further programmed:

when each of said first and said second time ratio is less than said predetermined threshold ratio, to provide input to said electrodes causing a duration of each said rest-time to be increased; and

when each of said first and said second time ratio is equal to or greater than said predetermined threshold ratio, to provide input to said electrodes causing a voltage provided by said electrodes to be increased and a duration of each said rest time to be decreased to a predetermined minimum rest-time value.

60. The device of any one of claims 51 to 59, said processing unit further programmed to provide input to said electrodes causing adaptation to a phase width of at least one said positive phase or at least one said negative phase.

61. The device of claim 60, said processing unit further programmed to provide input to said electrodes causing adaptation to a phase width of each said positive phase and each said negative phase.

62. The device of any one of claims 51 to 61, said electrodes configured to deliver a said pulse wherein a duration of said positive phase train is different from a duration of said negative phase train.

63. The device of any one of claims 51 to 62, said electrodes configured to deliver a said pulse wherein said cumulative duration of said positive phases is different from said cumulative duration of said negative phases.

64. The device of any one of claims 51 to 63, said electrodes configured to deliver a said pulse wherein said cumulative duration of said rest times between said positive phases in said positive phase train is different from said cumulative duration of said rest times between said negative phases in said negative phase train.

65. The device of any one of claims 51 to 64, said electrodes configured to deliver a said pulse wherein a number of said positive phases in said positive phase train is different from a number of said negative phases in said negative phase train.

66. The device of any one of claims 48 to 61, said electrodes configured to deliver a said pulse wherein a duration of said positive phase train is equal to a duration of said negative phase train.

67. The device of any one of claims 48 to 61, said electrodes configured to deliver a said pulse wherein said cumulative duration of said positive phases is equal to said cumulative duration of said negative phases.

68. The device of any one of claims 48 to 61, said electrodes configured to deliver a said pulse wherein said cumulative duration of said rest times between said positive phases in said positive phase train is equal to said cumulative duration of said rest times between said negative phases in said negative phase train.

69. The device of any one of claims 48 to 61, said electrodes configured to deliver a said pulse wherein a number of said positive phases in said positive phase train is equal to a number of said negative phases in said negative phase train.

70. The device of any one of claims 48 to 69, further comprising a body member adapted to be donned on the head of a user, wherein said electrodes and said sensor are mounted onto an inner surface of said body member.

71. The device of any one of claims 48 to 70, wherein the region of the head is a hair covered region of the head.

72. The device of claim 71, wherein said electrodes are configured, when the head mounted device is donned, to engage said hair covered region of the head.

73. The device of any one of claims 48 to 72, wherein said region of the head comprises a cephalic nerve, such that said electrodes are configured to deliver said electrical stimulation to said cephalic nerve in said region of the head.

74. The device of any one of claims 48 to 73, said electrodes configured to deliver a said pulse wherein a duration of each said rest time in said positive phase train and in said negative phase train is at least equal to a minimum rest time duration.

75. The device of any one of claims 48 to 74, said electrodes configured to deliver a said pulse wherein a phase width of each of said positive phases and of each of said negative phases is not greater than a maximal phase width.

76. The device of any one of claims 48 to 75, wherein said at least one sensor is at least one of said electrodes.

77. The device of any one of claims 48 to 76, wherein said at least one sensor is external to said electrodes and is functionally associated with said electronic circuit.

78. The device of any one of claims 48 to 77, wherein said at least one sensor is configured to monitor a provided waveform of each of said positive and said negative phases, and wherein said processing unit is configured to identify, for each said positive and said negative phase, whether the provided waveform is identical to an intended waveform, and to identify said reduction of charge if said provided waveform is not identical to said intended waveform.

79. The device of any one of claims 48 to 78, wherein said processing unit is configured to provide to said electrodes instruction for adapting at least one of said first time ratio and said second time ratio.

80. The device of claim 79, wherein said processing unit is configured to provide to said electrodes instruction for adapting said first time ratio and said second time ratio.

81. The device of any one of claims 48 to 80, wherein said processing unit is configured to provide to said electrodes instructions for changing a number of said positive phases in said positive phase train.

82. The device of any one of claims 48 to 81, wherein said processing unit is configured to provide to said electrodes instructions for changing a number of said negative phases in said negative phase train.

83. The device of any one of claims 48 to 82, wherein said processing unit is configured to provide to said electrodes instructions for changing an amplitude of at least one of said positive phases and said negative phases.

84. The device of any one of claims 48 to 83, wherein said at least one sensor is configured to monitor impedance in said electronic circuit, and said processing unit is configured to identify said impedance exceeding an impedance threshold.

85. The device of any one of claims 48 to 84, wherein said at least one sensor is configured to monitor a voltage delivered by said electrodes, and said processing unit is configured to identify said voltage reaching an upper voltage threshold.

86. The device of any one of claims 48 to 85, wherein, following said processing unit identifying that said predetermined amount of charge has been provided by each of said positive and said negative phases and completion of said step (d), said processing unit is configured to receive additional input at least from said at least one sensor and to identify at least one of a change in the charge delivered by said positive and said negative phases and a change in conditions in which said positive and said negative phases are provided.

87. The device of claim 86, wherein said at least one sensor is configured to measure a change in impedance between said at least two electrodes and to provide said measurement to said processing unit as said additional input.

88. The device of any one of claims 86 or 87, further comprising a user interface functionally associated with said processing unit, wherein said additional input comprises input provided by the user via said user interface.

89. The device of any one of claims 86 to 88, further comprising a sensor functionally associated with said processing unit and configured to sense conditions in an area adjacent to said electrodes, and wherein said additional input comprises a signal provided from said

sensor to said processing unit, the signal indicating a change in sensed conditions in an area adjacent said electrodes.

90. The device of any one of claims 86 to 89, said processing unit further configured, following identification of said change in conditions, to repeat said steps (c) and (d).

91. The device of any one of claims 48 to 90, further comprising a user notification module functionally associated with said processing unit and wherein, following at least one of said first time ratio and said second time ratio reaching said predetermined threshold ratio and said voltage reaching said predetermined voltage threshold, said processing unit terminates application of said electrical stimulation, and said user notification module notifies said user that treatment has been terminated.

92. The device of any one of claims 48 to 91, wherein:

said electrodes are configured to deliver, prior to delivery of said positive phase train and said negative phase train, a balanced singular constant-current pulse comprising a positive phase immediately followed by a negative phase, said positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

said processing unit is configured to identify, prior to delivery of said positive phase train and said negative phase train, that impedance in said electronic circuit during delivery of said singular pulse has reached a predetermined impedance threshold.

93. The device of any one of claims 48 to 92, wherein:

said electrodes are configured to deliver, prior to delivery of said positive phase train and said negative phase train, a balanced singular constant-current pulse comprising a positive phase immediately followed by a negative phase, said positive and negative phases intended to provide a predetermined amount of charge to the head of the user; and

said processing unit is configured to identify, prior to delivery of said positive phase train and said negative phase train that a voltage required to deliver said singular constant current pulse has reached an upper voltage threshold.

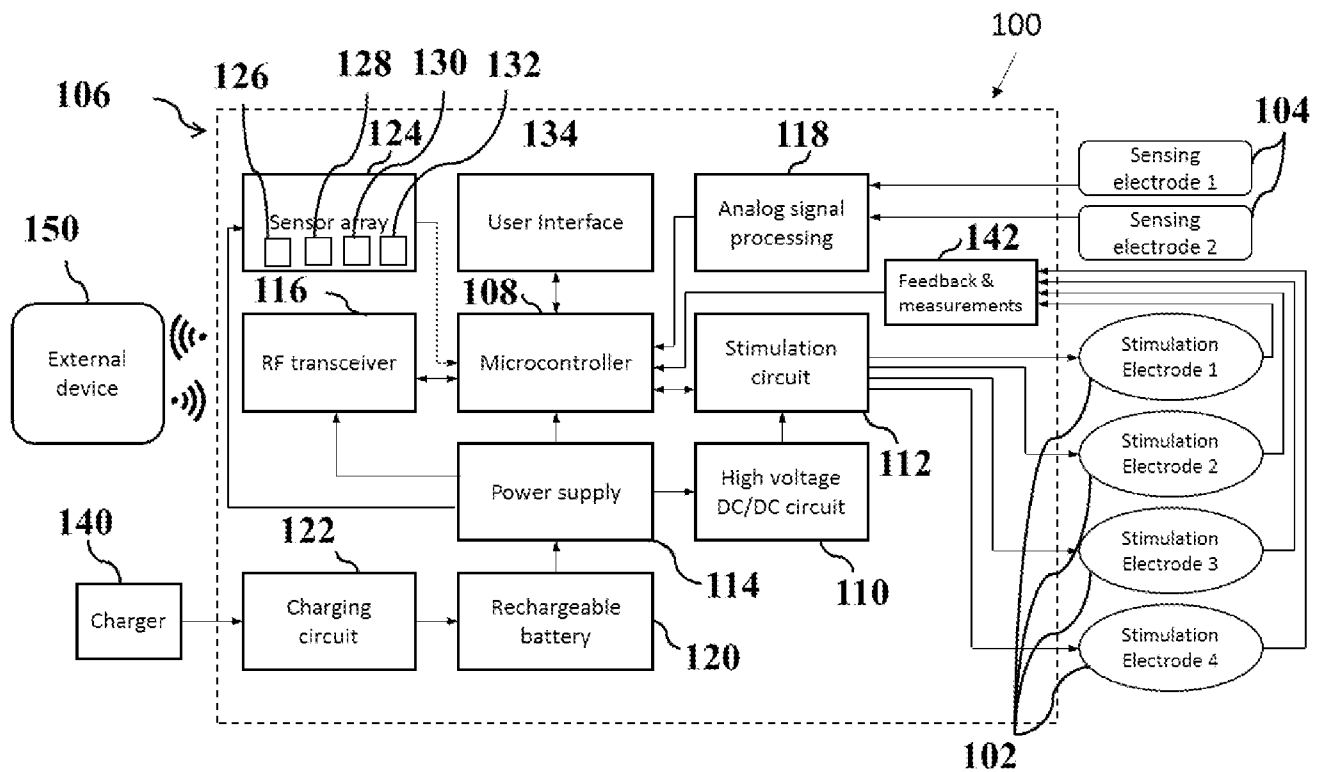


Fig. 1A

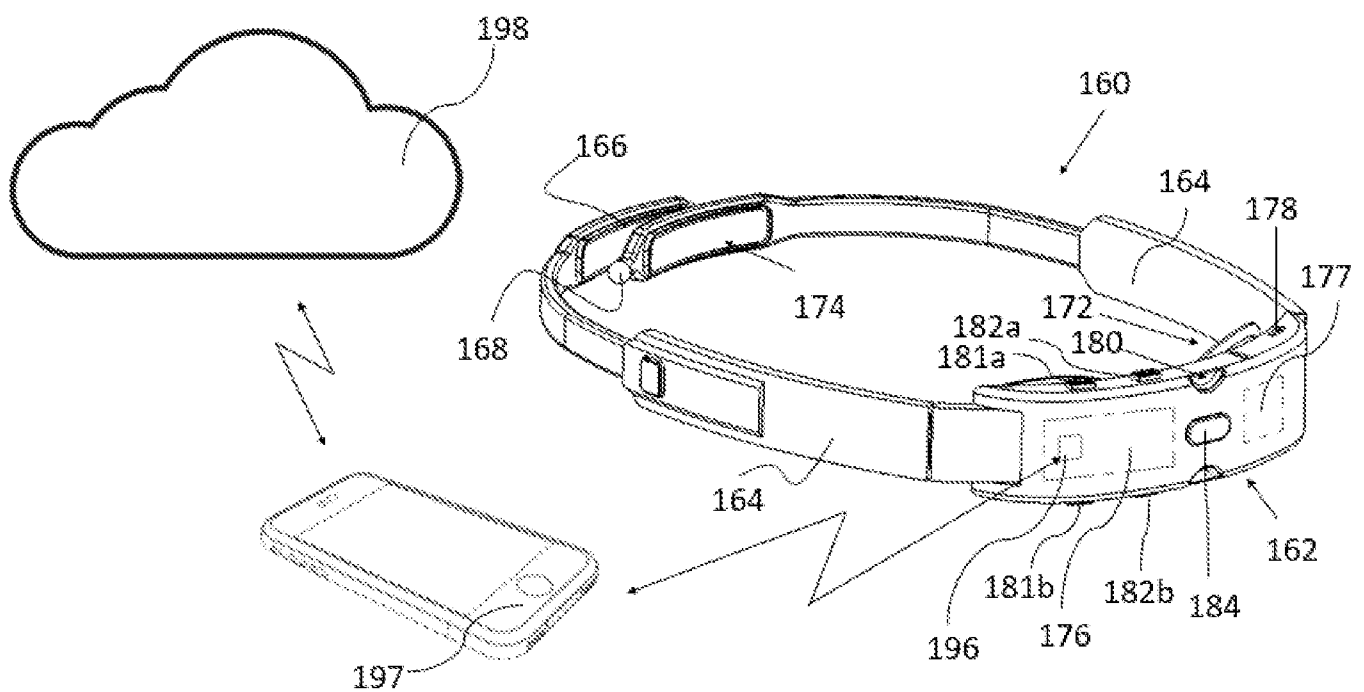


Fig. 1B

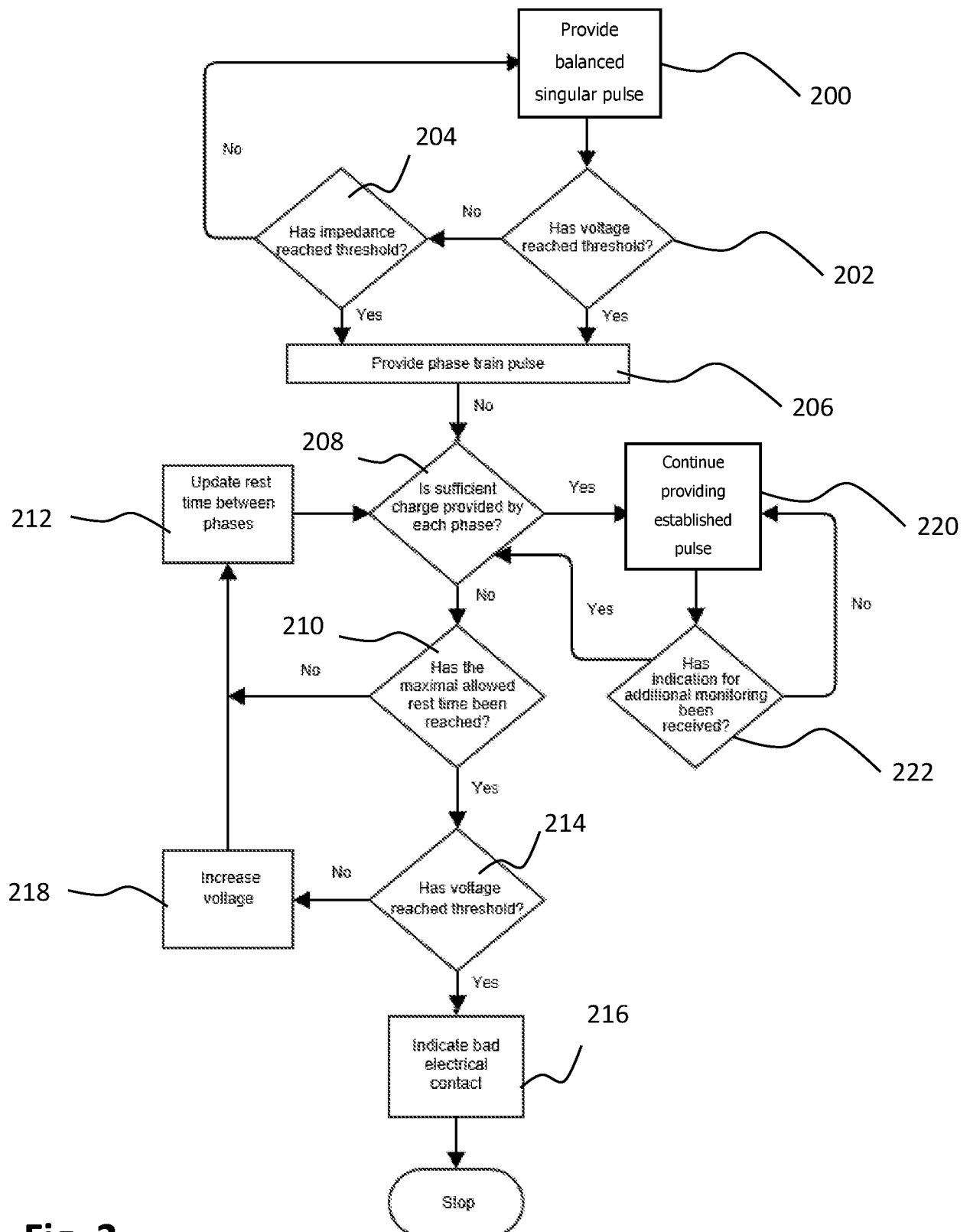


Fig. 2

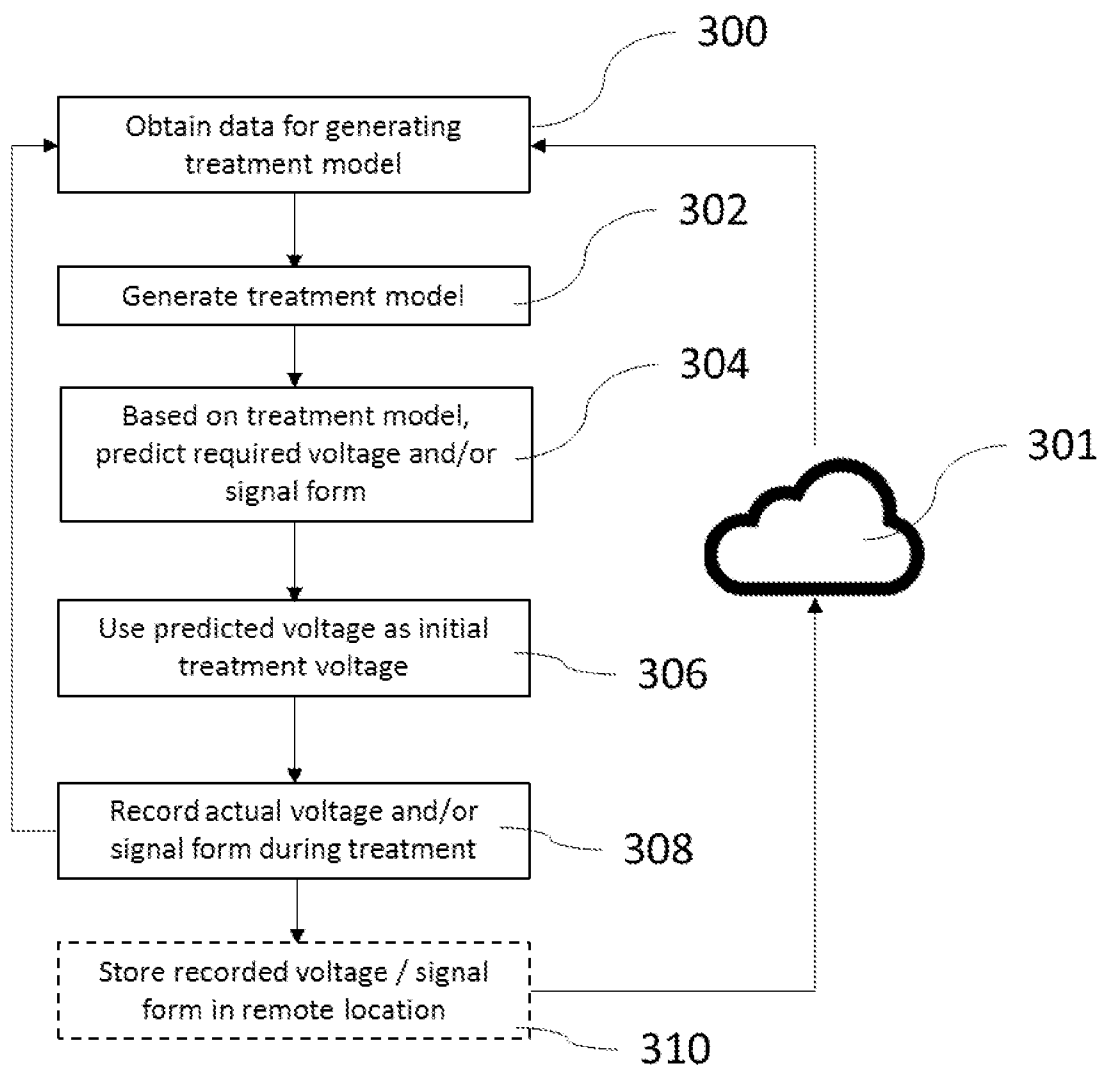
**Fig. 3**

Fig. 4A

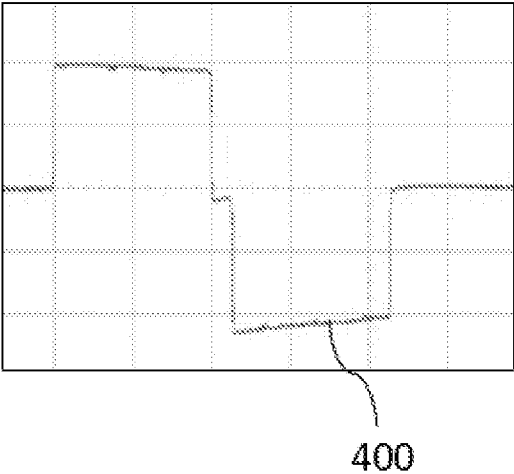


Fig. 4B

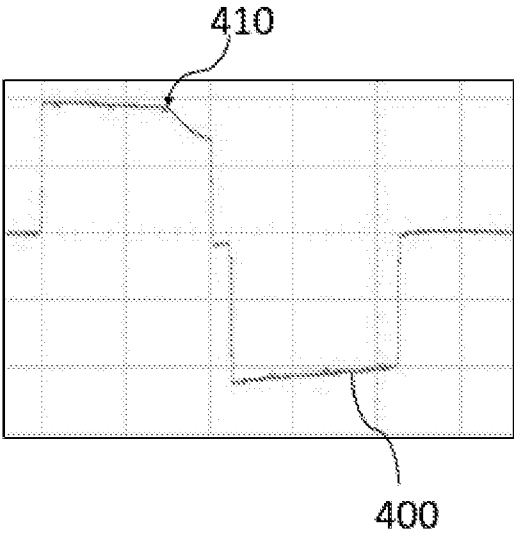
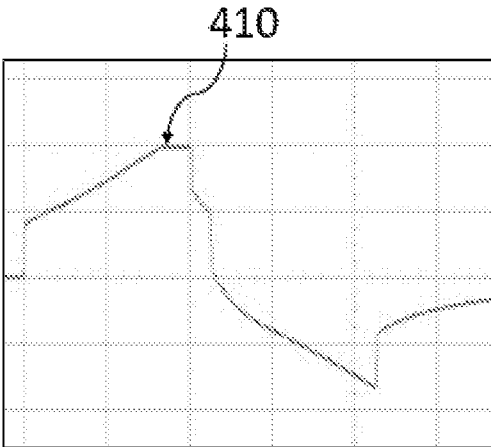


Fig. 4C



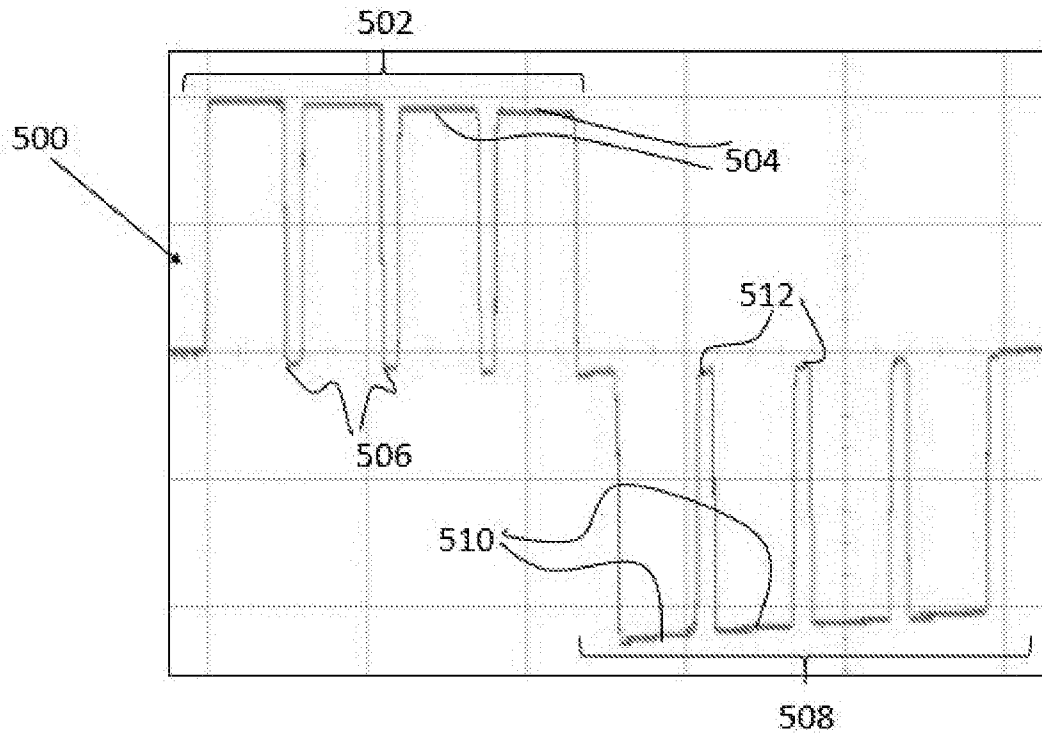


Fig. 5A

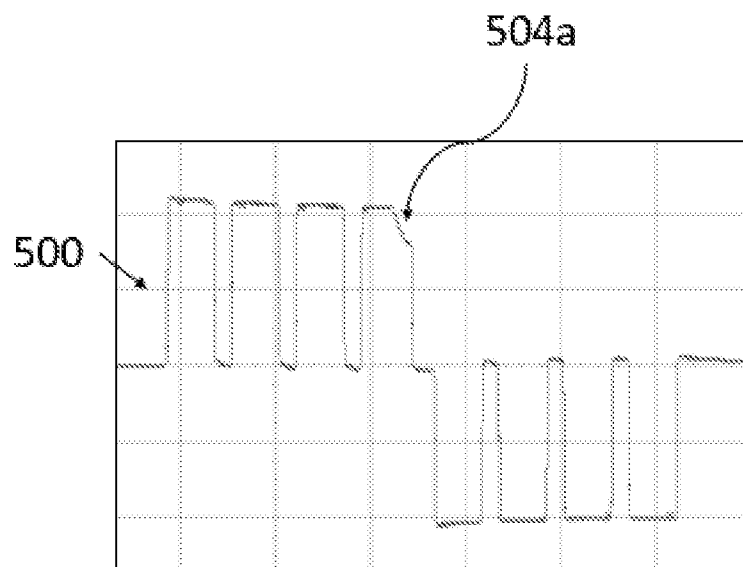


Fig. 5B

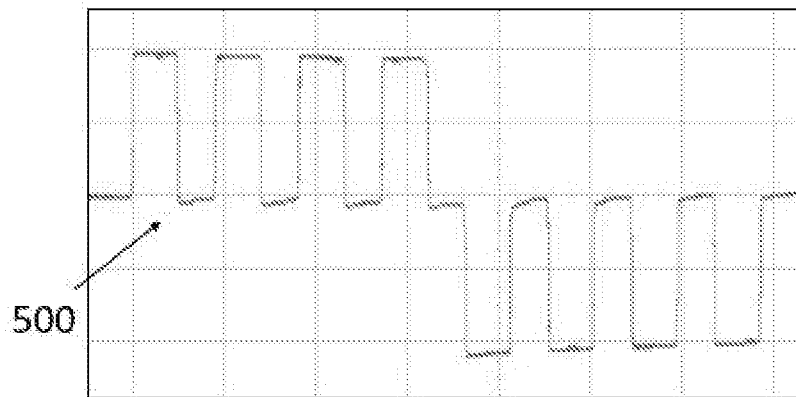


Fig. 5C

600					
	cumulative rt. (usec)	cumulative rt. (%)	Voltage	V decrees (%)	Paresthesia comparing to the base line (10-1)
Base line	0	0	89	0.0	10
Pulse train	60	15	83	6.7	9
	100	25	79	11.2	9
	140	35	73	18.0	8
	240	60	65	27.0	8
	320	80	55	38.2	7
	400	100	47	47.2	6
	600	150	35	52.1	4
	800	200	26	70.8	1

Fig. 6A

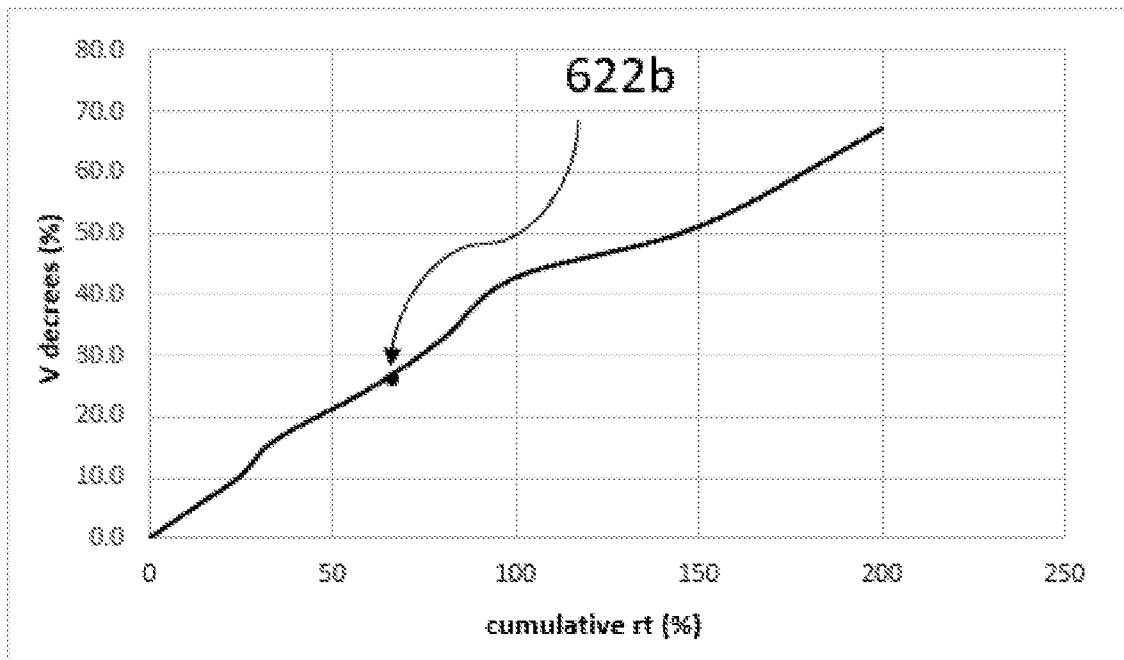


Fig. 6B

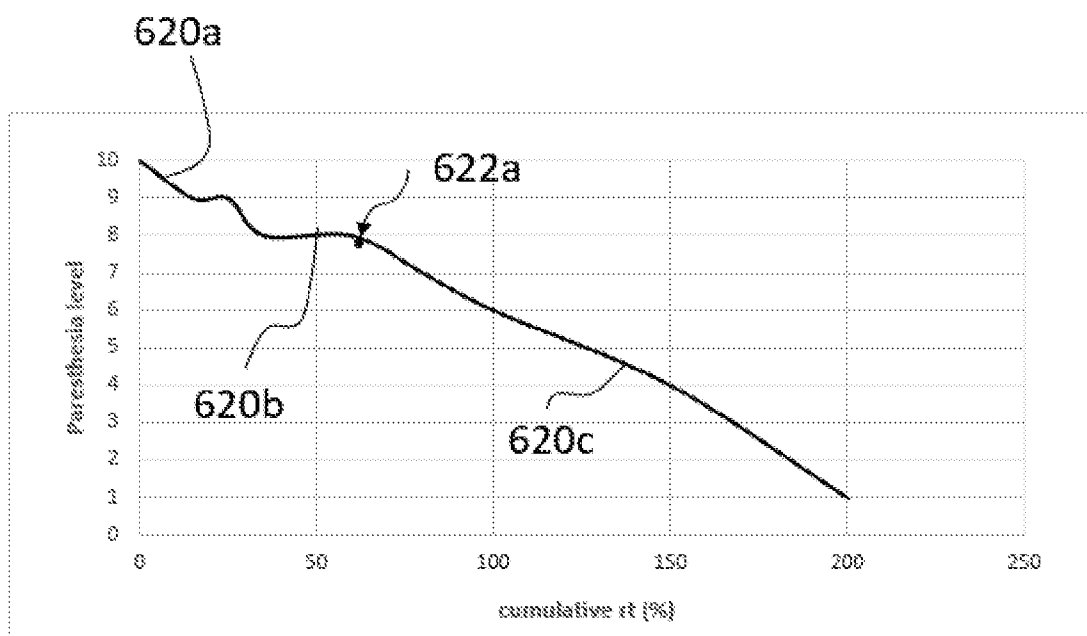


Fig. 6C

INTERNATIONAL SEARCH REPORT

International application No.

PCT/IB2017/052045

A. CLASSIFICATION OF SUBJECT MATTER IPC (2017.01) A61N 1/00 According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) IPC (2017.01) A61N 1/00 Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) Databases consulted: THOMSON INNOVATION, Esp@cenet, Google Patents Search terms used: Control*, adjust*, shap*, pattern*, modulat*, parameter, width*, duty cycle, amplitude, frequency, OR polar*, stimulat*, electrode*, train pulses, bipolar pulses, biphasic pulses, current feedback, charge feedback		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2006173493 A1 Cyberonics, Inc. 03 Aug 2006 (2006/08/03) (The whole document especially abstract, Figs. 1A-1D, 2-4, 4A-4F, 5-8).	1-25,48-69,71-93
Y	(The whole document especially abstract, Figs. 1A-1D, 2-4, 4A-4F, 5-8).	26-47,70
X	US 2014180364 A1 Cyberonics, Inc. 26 Jun 2014 (2014/06/26) (The whole document especially Figs. 1B, 3, 4a-4b, 5a-5B, 6A-6B, 7A-7C, 8A-8F, 9, 11, paragraphs 48, 71).	1-25,48-69,71-93
Y	(The whole document especially Figs. 1B, 3, 4a-4b, 5a-5B, 6A-6B, 7A-7C, 8A-8F, 9, 11, paragraphs 48, 71).	26-47,70
Y	US 4638807 A Ryder International Corporation, Arab Ala 27 Jan 1987 (1987/01/27) (The whole document especially abstract, Figs. 1-8).	26-47,70
<input checked="" type="checkbox"/> Further documents are listed in the continuation of Box C. <input checked="" type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 11 Jul 2017		Date of mailing of the international search report 17 Jul 2017
Name and mailing address of the ISA: Israel Patent Office Technology Park, Bldg.5, Malcha, Jerusalem, 9695101, Israel Facsimile No. 972-2-5651616		Authorized officer NIMER Emad Telephone No. 972-2-5657801

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C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
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A	US 2011082524 A1 ARP MFG LLC?(US) 07 Apr 2011 (2011/04/07) (The whole document especially abstract, Figs. 2-21, paragraphs 4, 5, 1943, 44-57).	1-93
A	US 6871090 B1 Advanced Bionic Corp (US) 22 Mar 2005 (2005/03/22) (The whole document).	1-93
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				EP	2485796	A1	15 Aug 2012
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		US 9078801 B2	14 Jul 2015
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